

CPMT Seminar

Printed Devices and Large Area Interconnect Technologies for New Electronics

Printed Organic Transistors for Ultraflexible and Stretchable Electronics

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The University of Tokyo

Outline

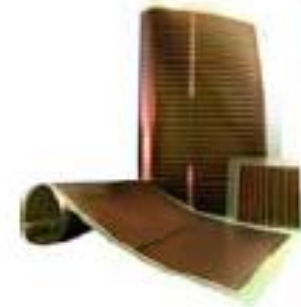
- **Background & Motivation**
 - ✓ **Organic integrated circuits on plastics**
- **All printed organic transistors**
- **Ultraflexible organic CMOS circuits**
 - [T. Sekitani et al., Nature Materials, 9, 1015 \(2010\).](#)
- **Stretchable integrated circuits**
 - [T. Sekitani et al., Science 321, 1468 \(2008\).](#)
 - [T. Sekitani et al., Nature Materials 8, 494 \(2009\).](#)
- **Future Prospects & Summary**

Flexible & Printed electronics

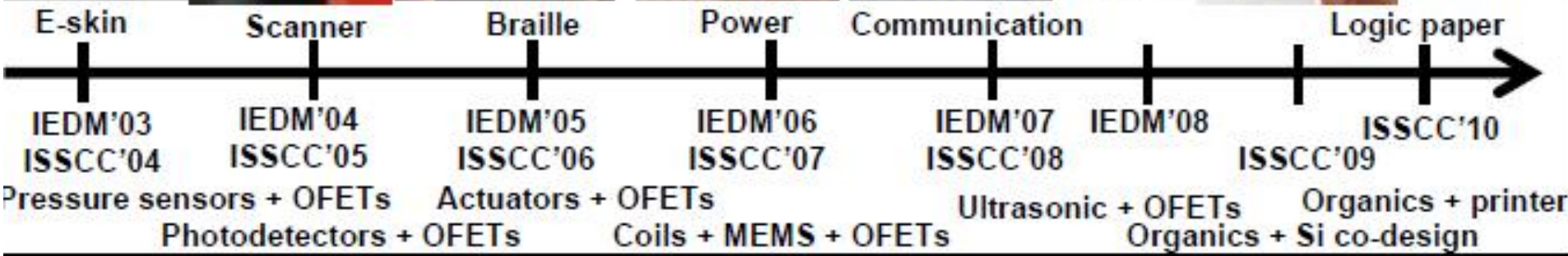
Flexible displays

PV

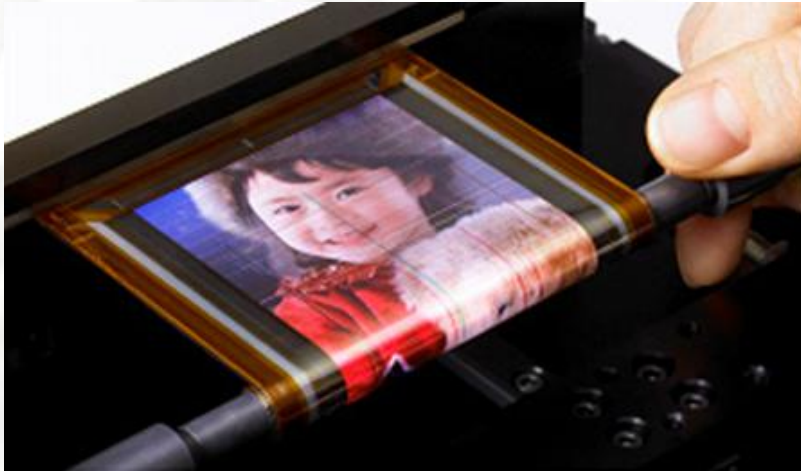
RFID



Large-area sensors and actuators



Flexible displays



SONY, SID 2010

From <http://www.sony.co.jp/SonyInfo/News/Press/201005/10-070>

- ✓ **Peri-Xanthenoxanthene (PXX) derivative**
→ **Mobility: $0.4 \text{ cm}^2/\text{Vs}$**
- ✓ **Organic driving cells with 2T-1C structure**
- ✓ **Resolutions: 121ppi ($432 \times 240 \times \text{RGB}$ pixels)**
- ✓ **Critical bending $R = 4 \text{ mm}$**

Flexible TFTs on *plastic*

	Poly-Si TFTs (ref. 1) EPSON	Oxide TFTs (ref. 2) TIT	CNT TFTs (ref. 3) Illinois U.	Organic TFTs (ref. 4) UT	a-Si TFTs (ref. 5) Princeton U.	Organic TFTs (ref. 6) Erlangen
Mobility	>10 cm ² /Vs	>7 cm ² /Vs	15 cm ² /vs	0.5 cm ² /Vs	0.5 cm ² /Vs	0.1 cm ² /Vs
Operation voltage	4 V	10 V	20 V	40 V	15 V	2.5 V
Bending radius	10 mm	30 mm	10 mm	0.5 mm	0.5 mm	2.5 mm

1. *Journal Soc. Inf. Displays* 16, 107(2008). 2. *Nature* 432, 488-492 (2004).
 3. *Appl. Phys. Lett.* 86, 243502 (2005). 4. *Appl. Phys. Lett.* 87, 173502 (2005).
 5. *Appl. Phys. Lett.* 96, 042111 (2010). 6. *Appl. Phys. Lett.* 95, 103309 (2009).

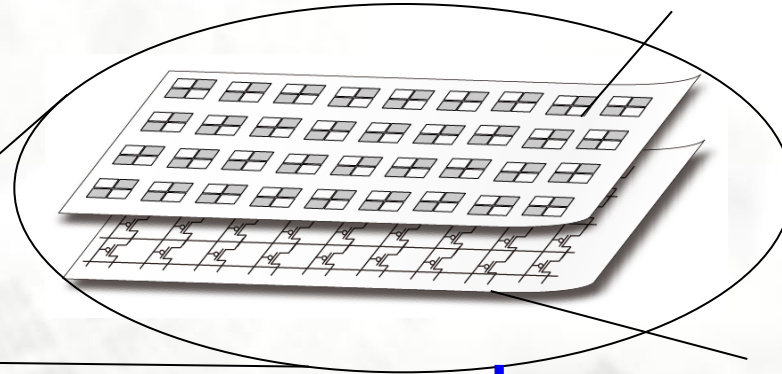
Organic TFTs can easily construct complementary circuits on plastics.
➔ Low-process temperatures & stable p-type, n-type semiconductors

Technical challenges for skin-like interfaces

→ Large-area & flexible active matrix

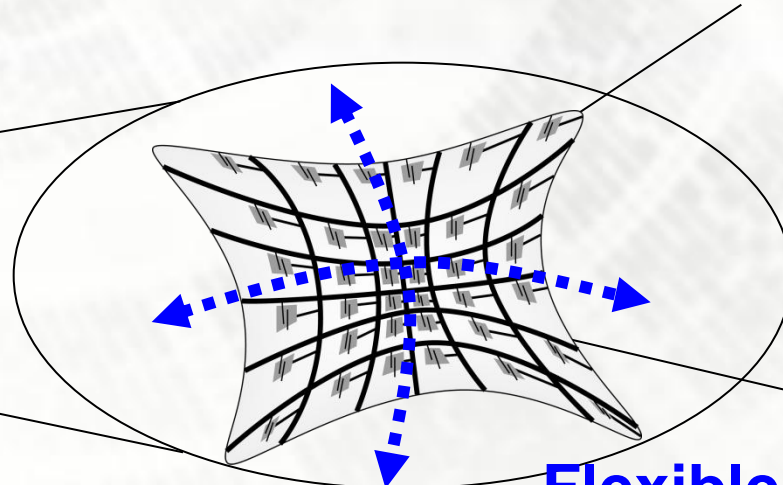
Sensor arrays
(light, pressure, thermal)

Position-sensing



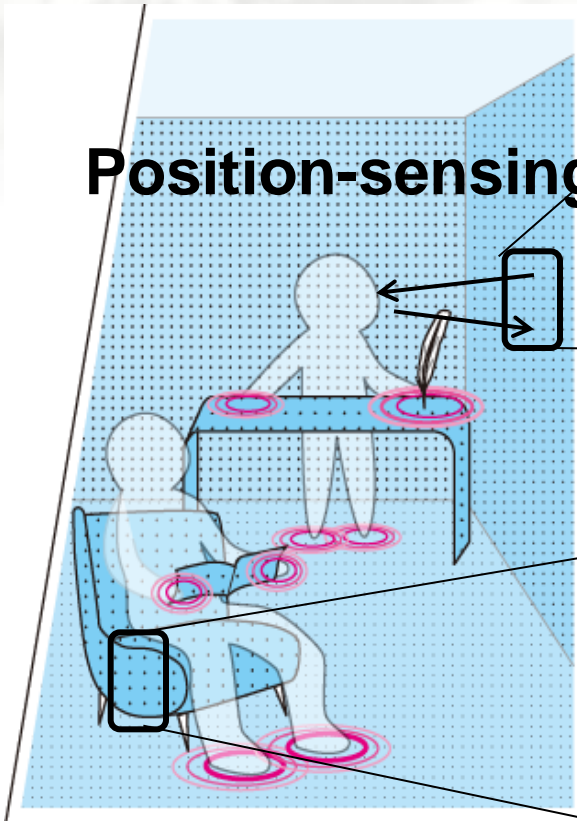
Key:1

Large-area Active Matrix



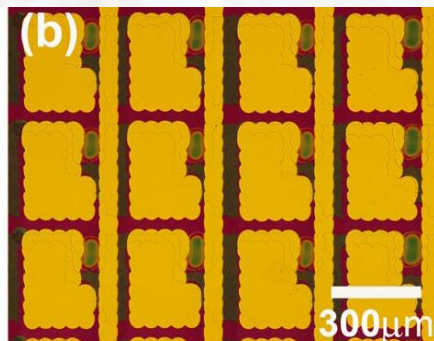
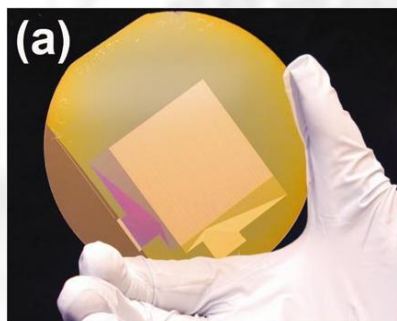
Key:2

Flexible & conformable



Printed TFT active matrices for displays

K. Yase, et al., (2008) AIST



Inkjet printing

Semiconductor: PQT

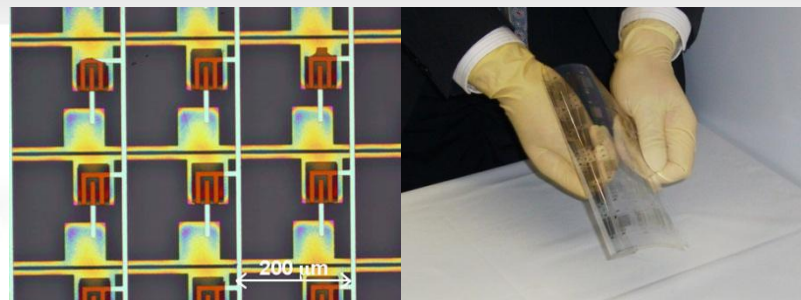
Mobility: $\sim 0.08 \text{ cm}^2/\text{Vs}$

340 μm pixel pitch

A. C. Arias, et al., (PARC)

Appl. Phys. Lett. 85, 3304

(2004)

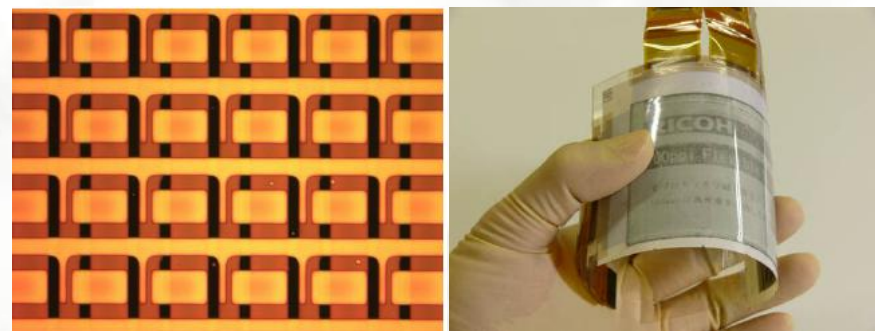


Micro-contact printing

Semiconductor: P3HT

Mobility: $\sim 0.01 \text{ cm}^2/\text{Vs}$

127 μm pixel pitch (200ppi)



Inkjet printing + UV

Semiconductor: Small molecule

Mobility: $\sim 0.1 \text{ cm}^2/\text{Vs}$

127 μm pixel pitch (200ppi)

K. Suzuki et al., IDW'09 (2009) RICOH 3.2 inch-diagonal

Screen-printing for Large-area electronics

Frame size: $3300 \times 3500 \text{ mm}^2$ (Accuracy $\pm 30 \mu\text{m}$)

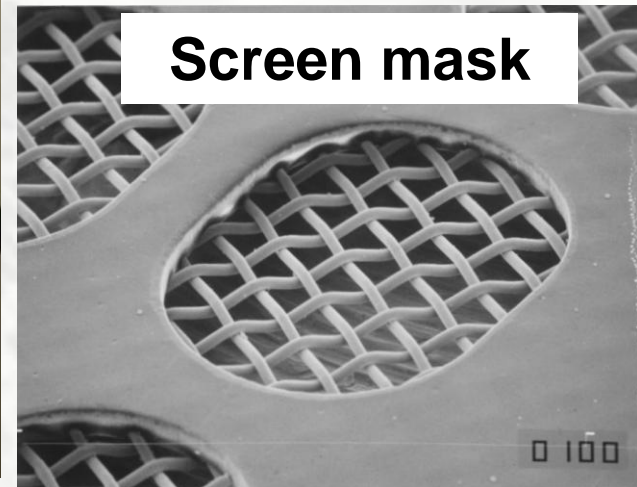
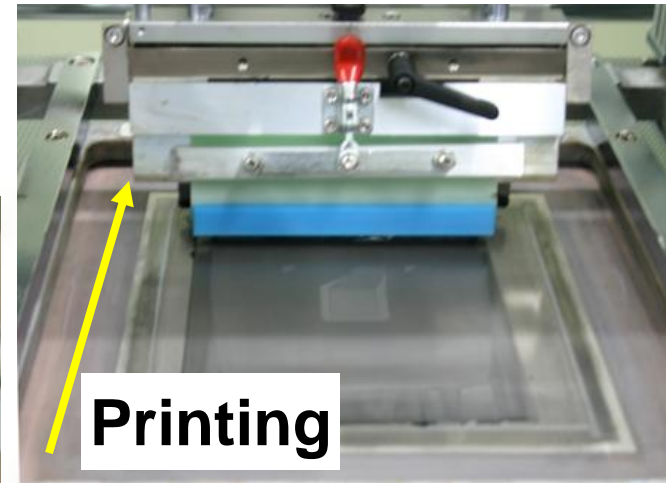
Tokyo process service Co, Ltd.,

Screen-printing system

Printing area : $300 \times 300 \text{ mm}^2$

Repeat accuracy : $5 \mu\text{m}$

Microtec Co. Ltd.



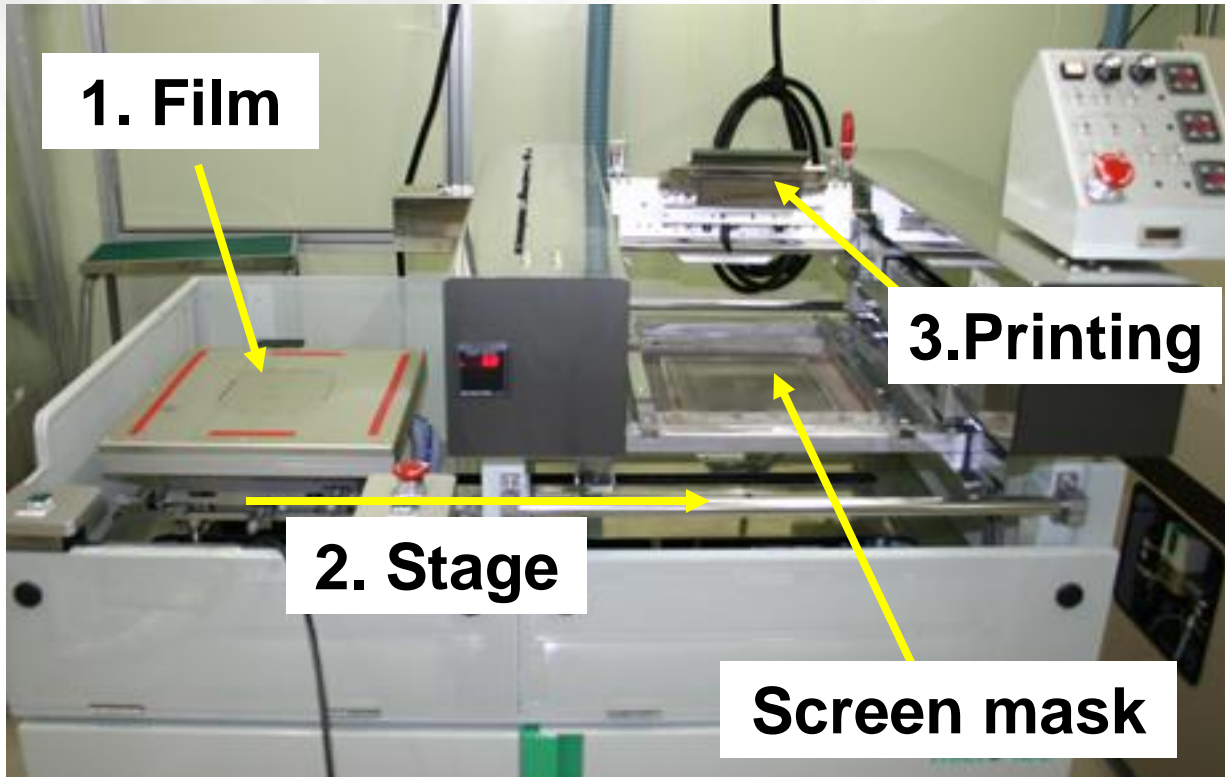
500 μm

1. Film

3. Printing

2. Stage

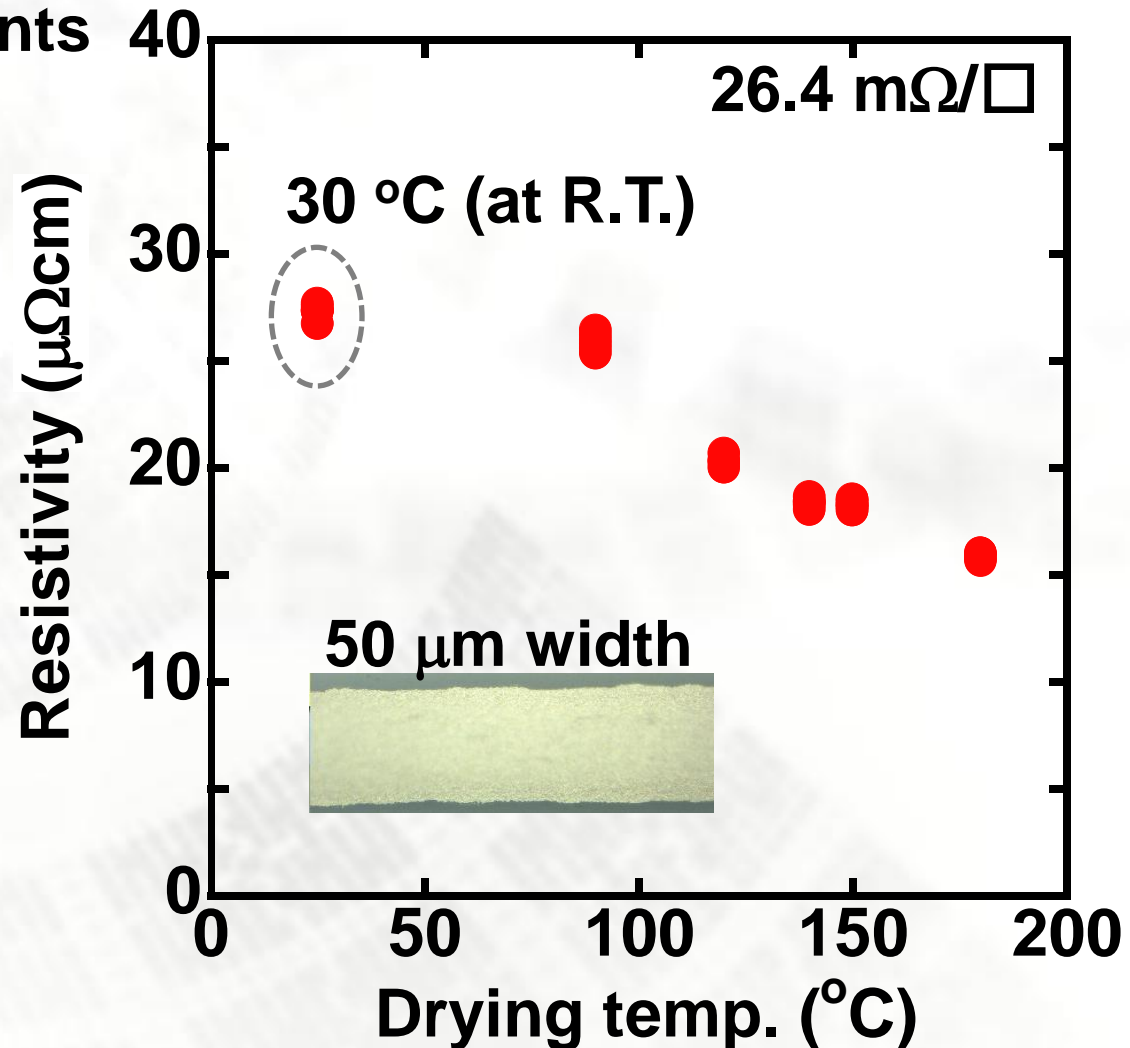
Screen mask



Ag paste with low-drying temperature

Viscosity: 360 Pa·s

→ very few organic solvents

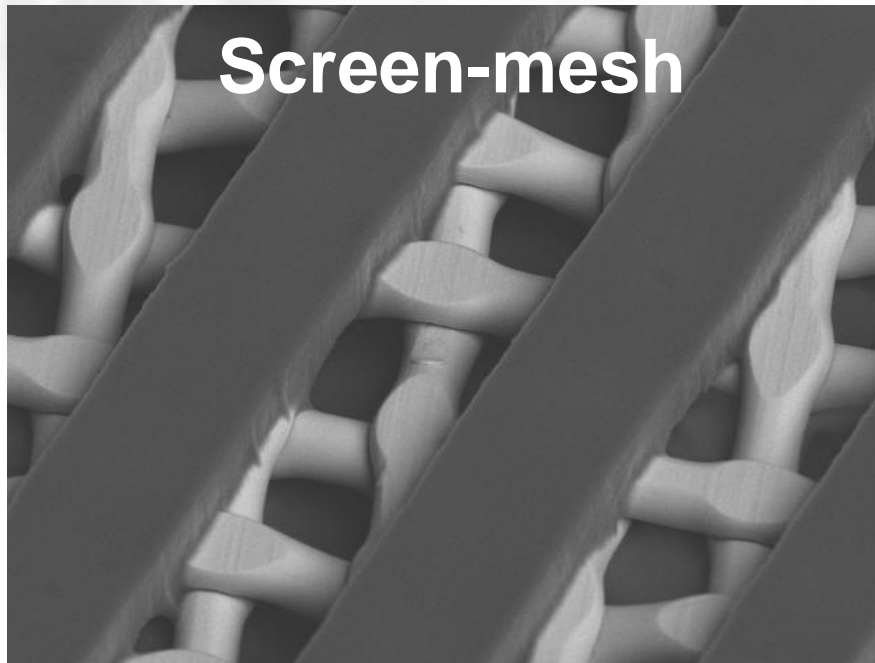


High-definition screen-printing

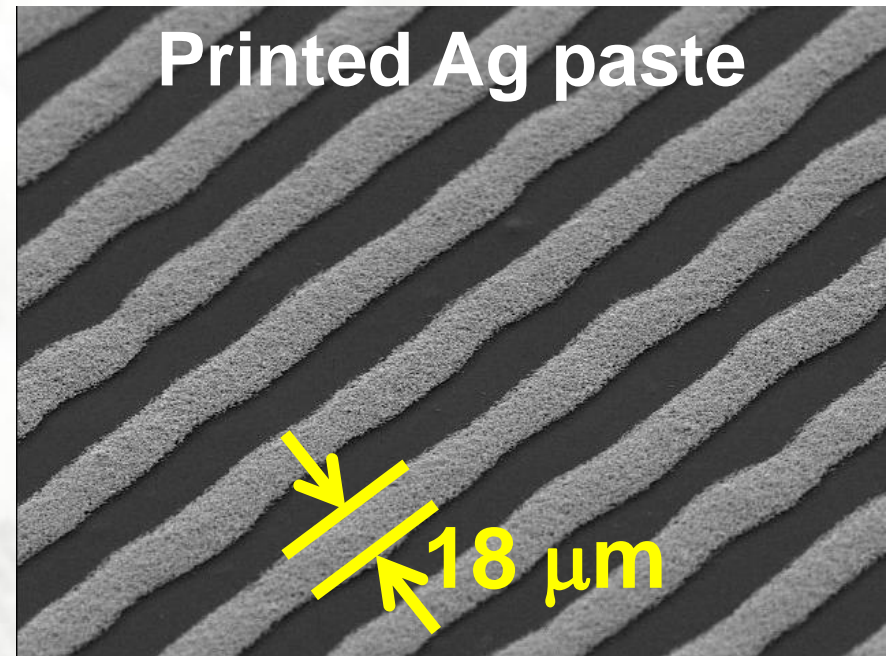
**High-viscosity
ink**

- ✓ High-squeezing pressure
- ✓ Large-clearance between screen-mask and substrate

This work



✓ **Twill-weaven mesh for high tensile force (3000 N/mm)**



✓ **Finely patterned without ink bleed**

Organic semiconductor ink

Solution – processable polycrystalline

organic semiconductor

lisicon OSC
(Merck Ltd.)

- High-mobility (4 cm²/Vs)
- Annealing is not required
- Air-stable

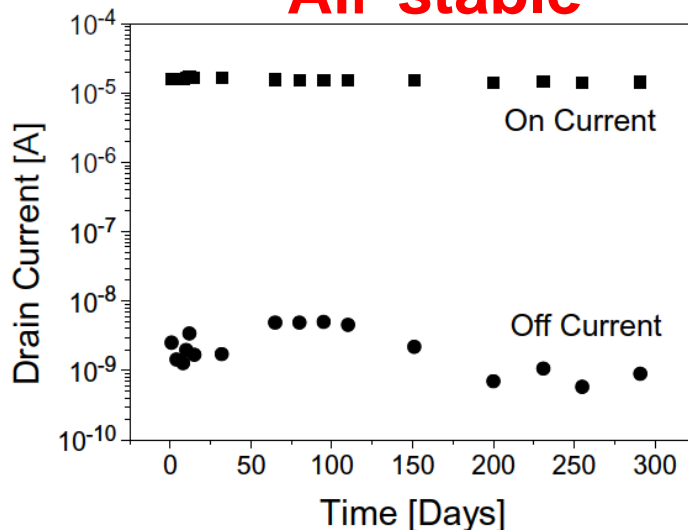
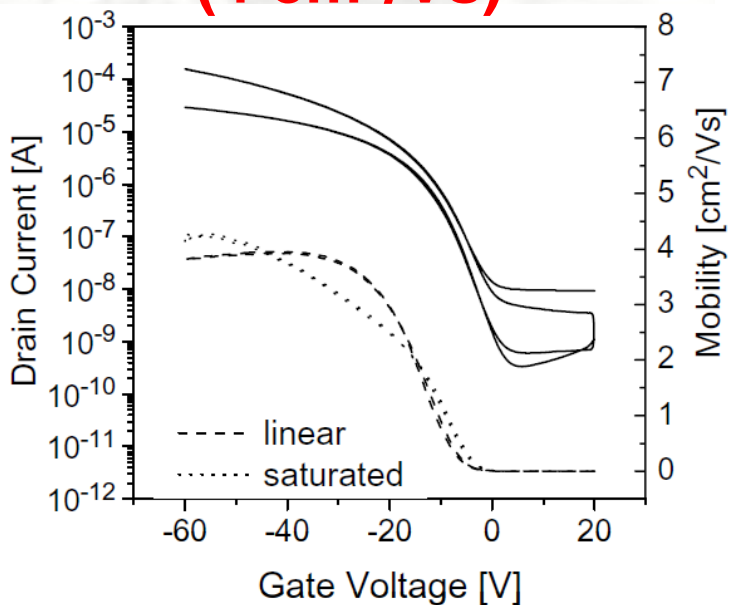


Fig. 3 Example lifetime data for a spin coated top gate device stored in normal laboratory conditions.



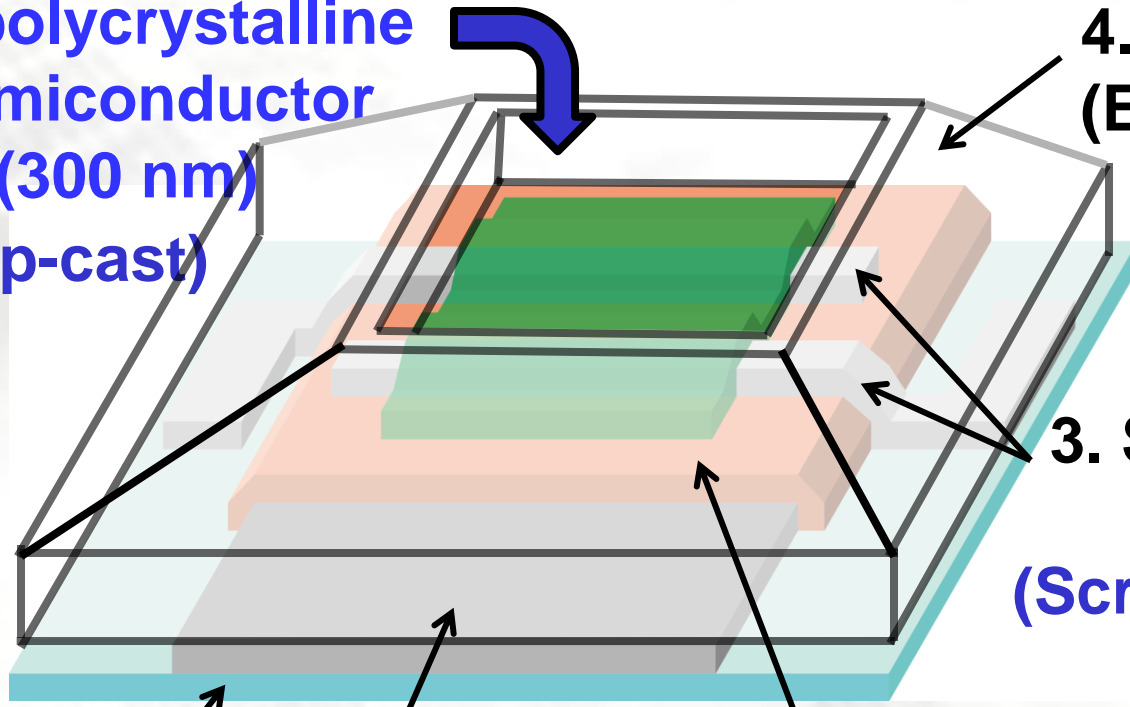
lisicon OSC
(Merck Ltd.)



G. Lloyd et al., *Tech Dig of IDW '08*
M. Carrasco-Orozco et al., *Tech Dig of IDW '09*
G. Lloyd et al., *Tech Dig of IDW '10*

Transistor fabrication by printing

5. Solution-polycrystalline
Organic semiconductor
Pentacene (300 nm)
(IJP, Drop-cast)



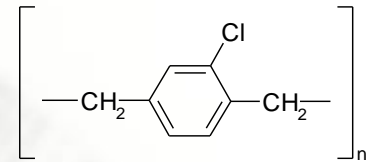
4. Bank
(Epoxy: 5 μm)
(Screen printing)

3. S/D electrode
(Ag: 5 μm)
(Screen printing)

2. Gate dielectric layer (CVD)
(parylene: 400 nm)

1. Gate electrode (Ag: 3 μm)
(Screen printing)

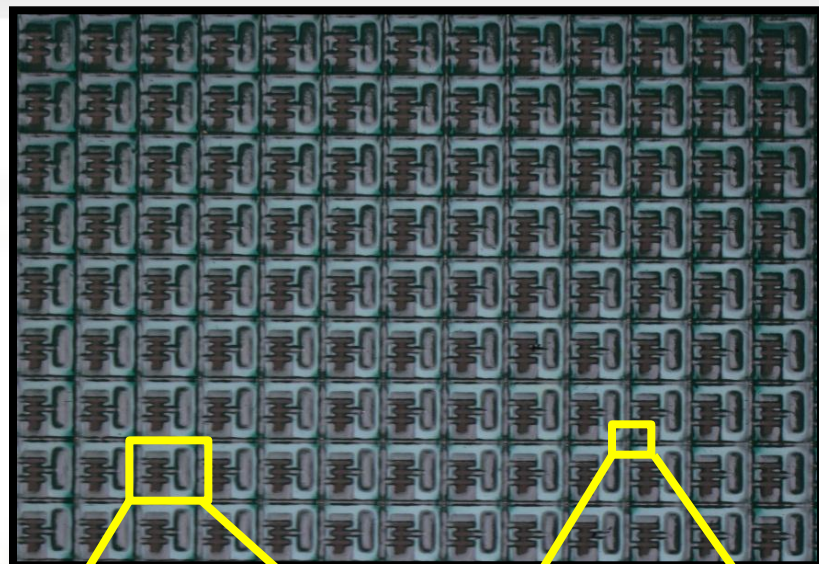
Substrate (PEN: 125 μm)



Dry at 3 hours in ambient air + Parylene encapsulation

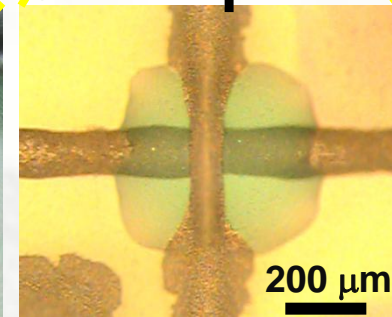
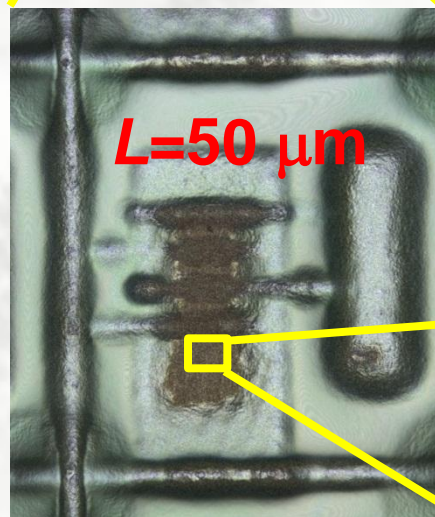
Printed transistor active matrix

300 x 300 mm²
(14,400 cells: 1mm pitch)

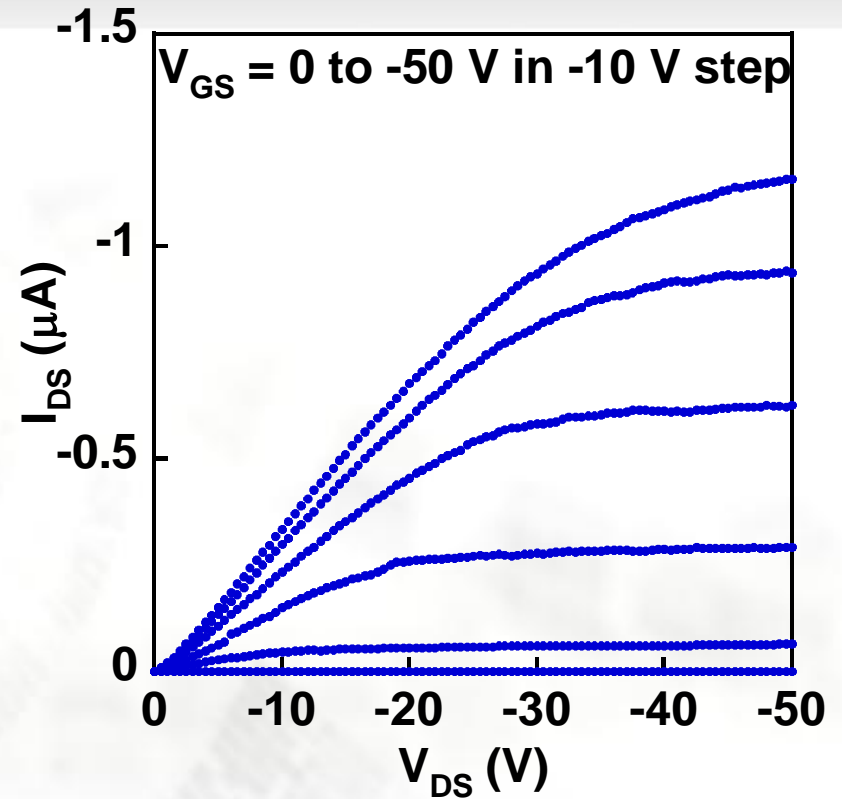
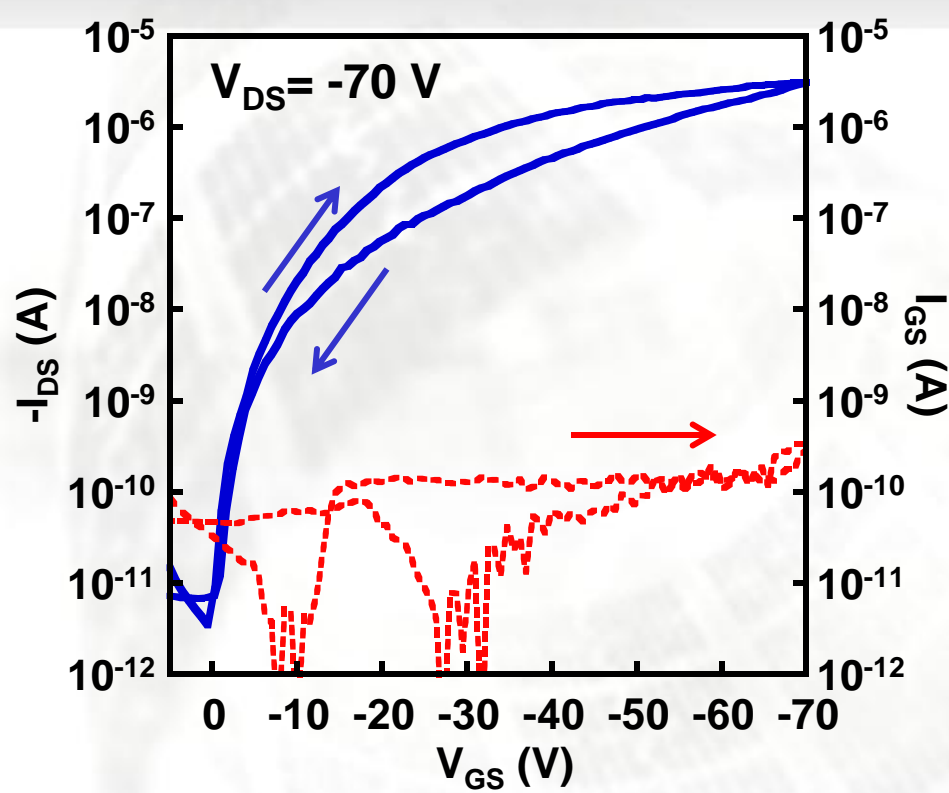


TFT

Cross-point



Polycrystalline organic TFT



Mobility : $\sim 0.18 \text{ cm}^2/\text{Vs}$

On/off ratio : $10^3 \sim 10^6$

In air

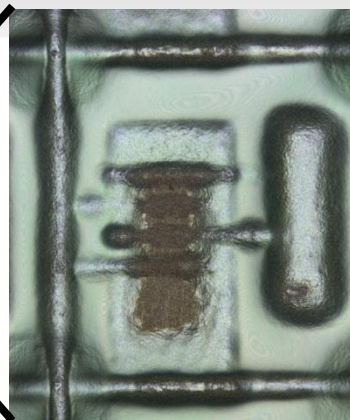
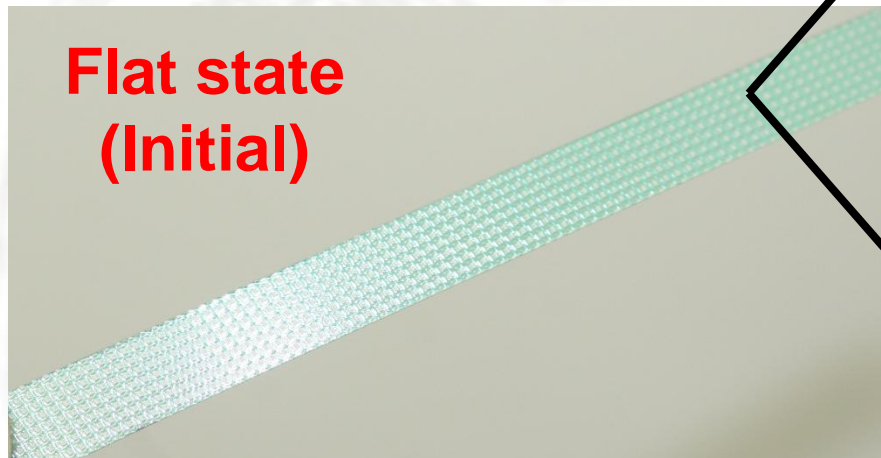
5 days

μ : $0.13 \text{ cm}^2/\text{Vs}$

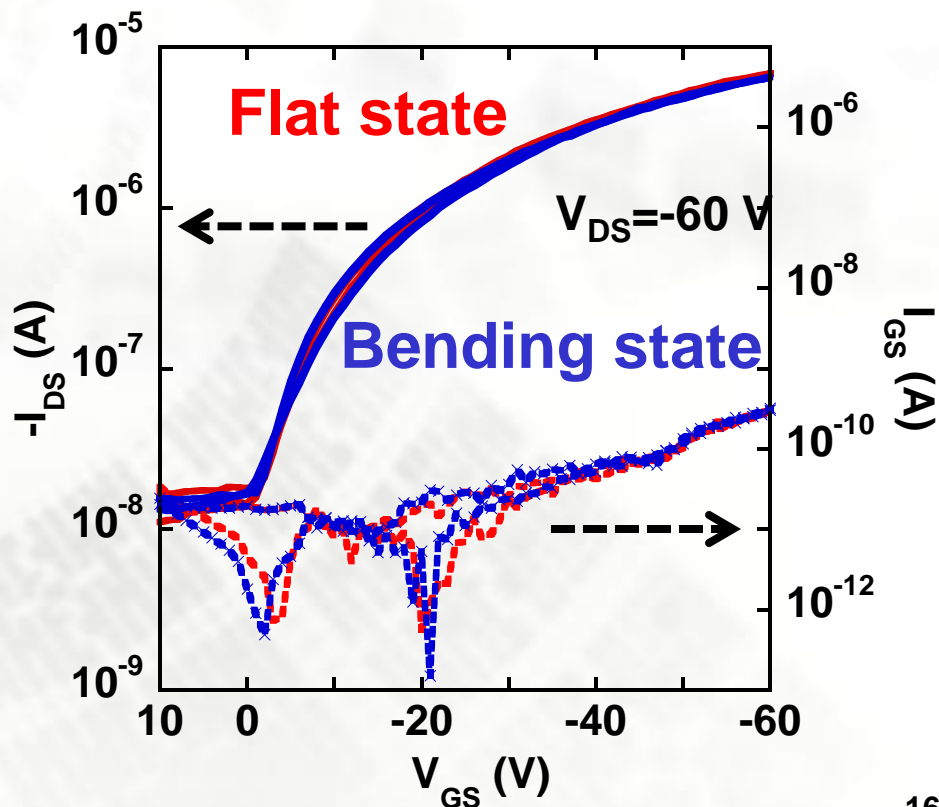
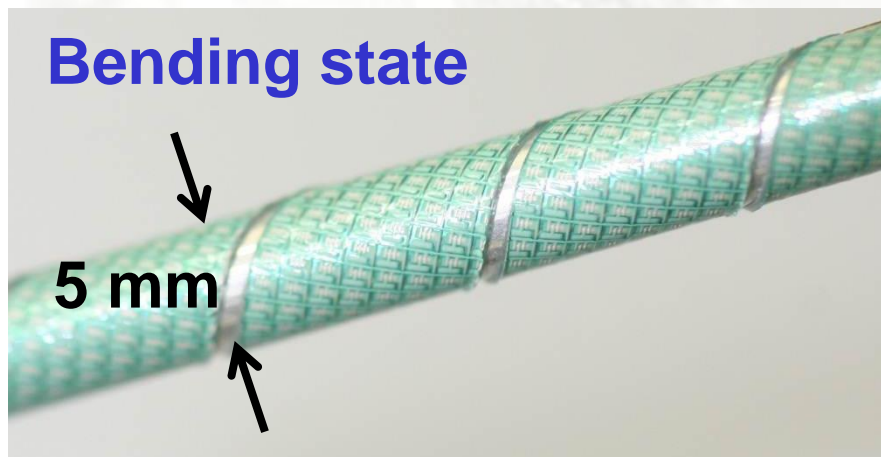
V_{TH} : -3.2 V

On/Off: $> 10^3$

Bending Test

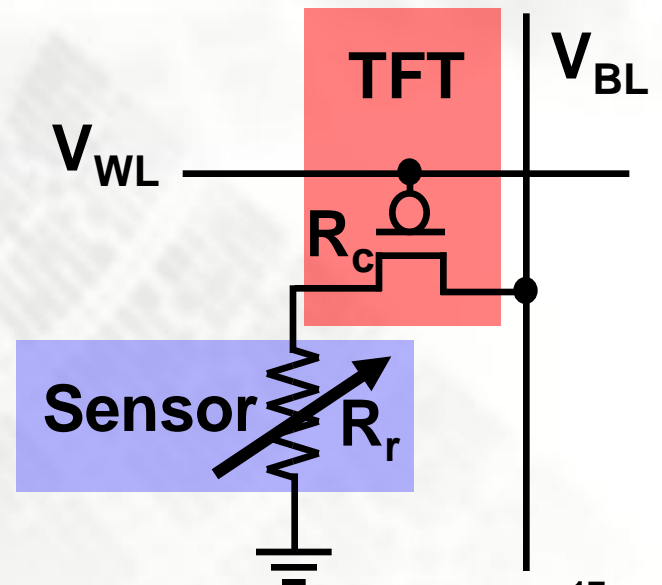
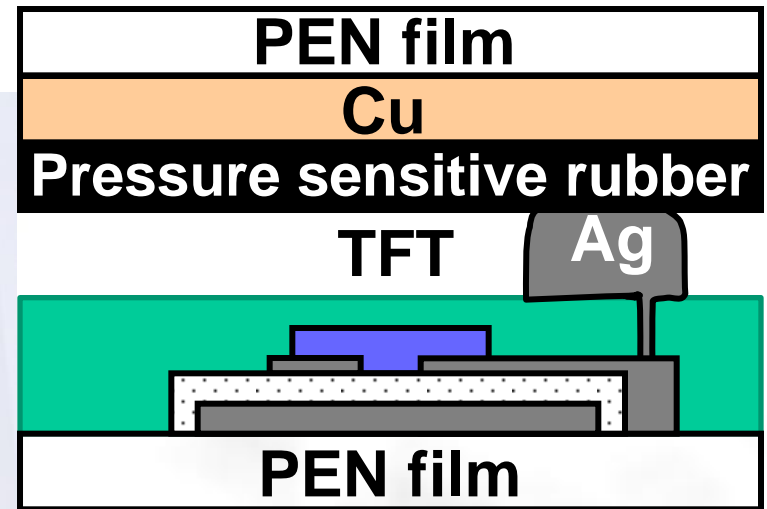
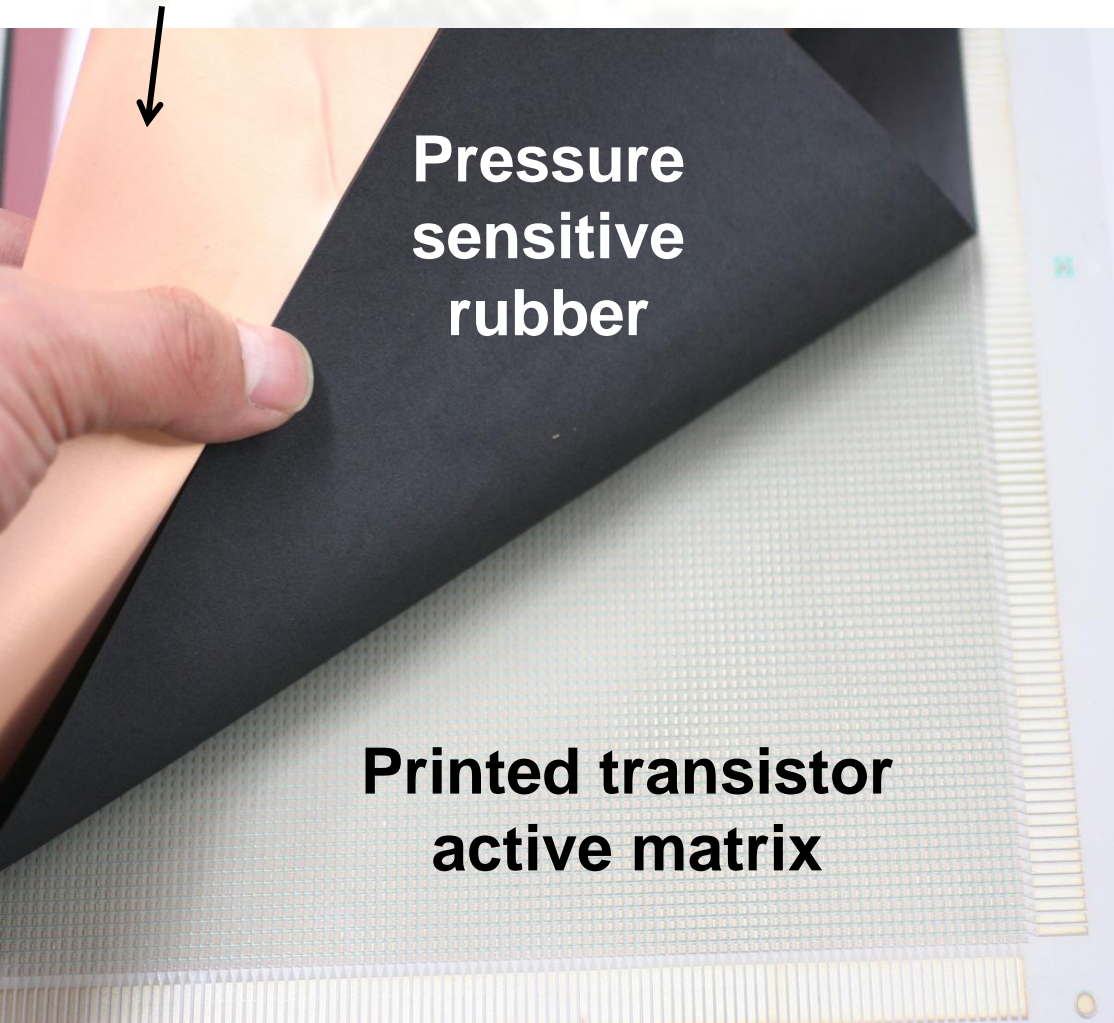


$L=50\ \mu\text{m}$



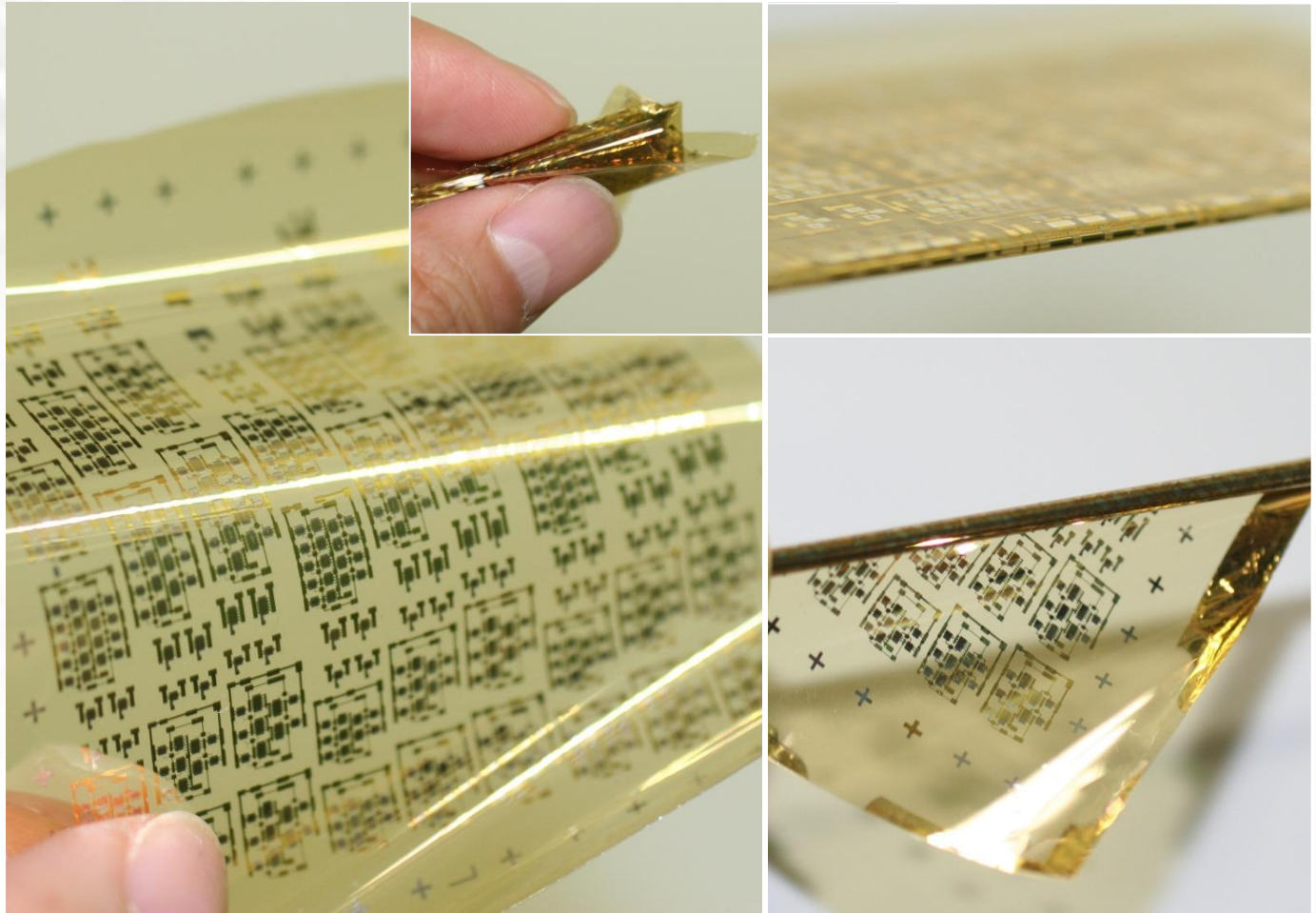
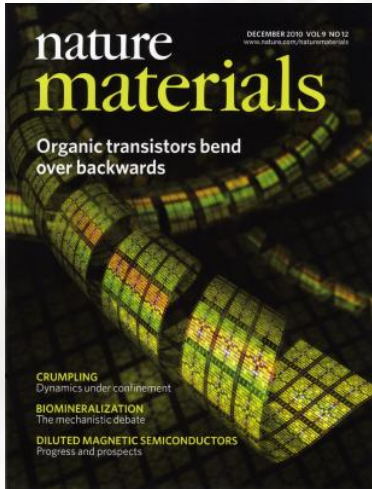
Flexible touch-sensor sheet

PET film with Cu electrode



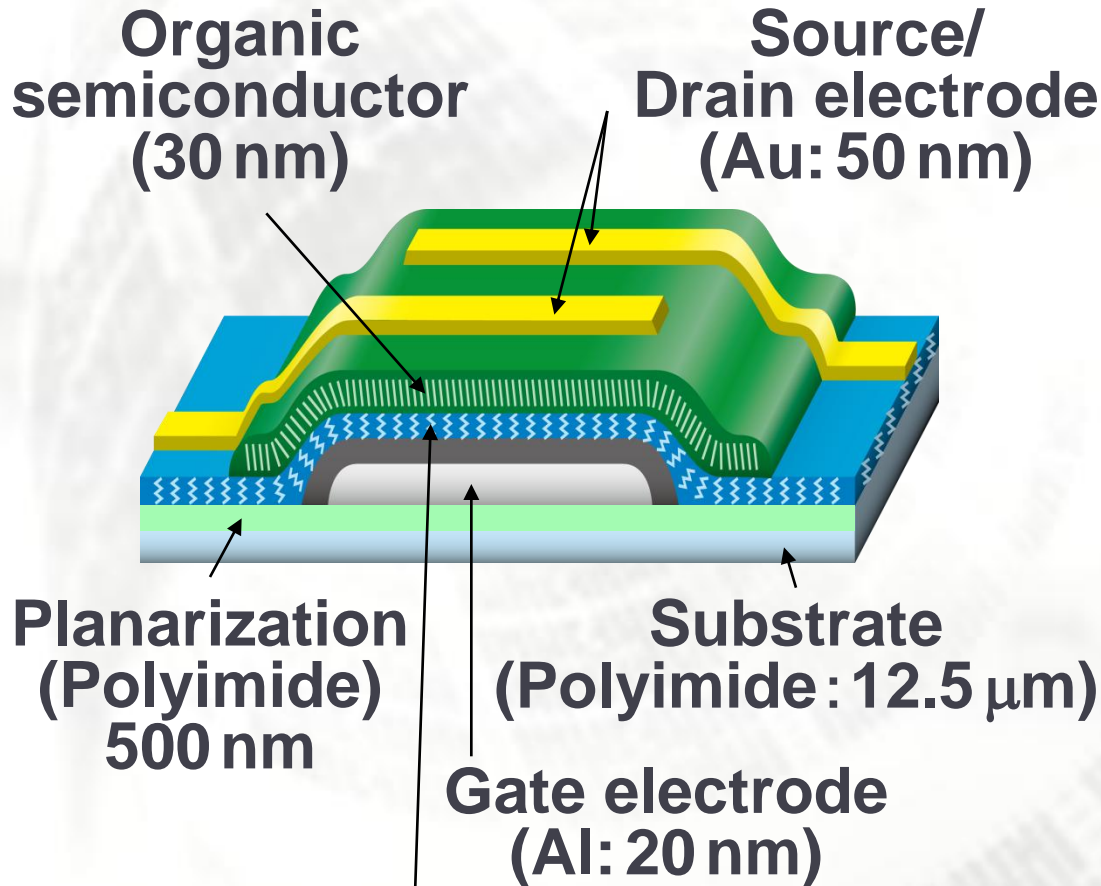


Low-voltage operational ultraflexible organic CMOS circuits

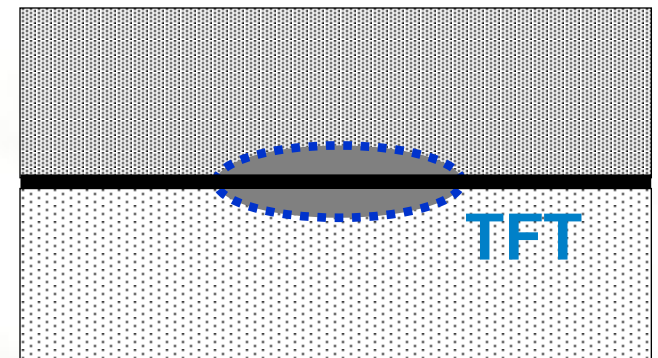


T. Sekitani, et al., Nature Materials, 9, 1015 (2010)

TFT structure



Encapsulation (13 μm)



Substrate + Planarization (13 μm)

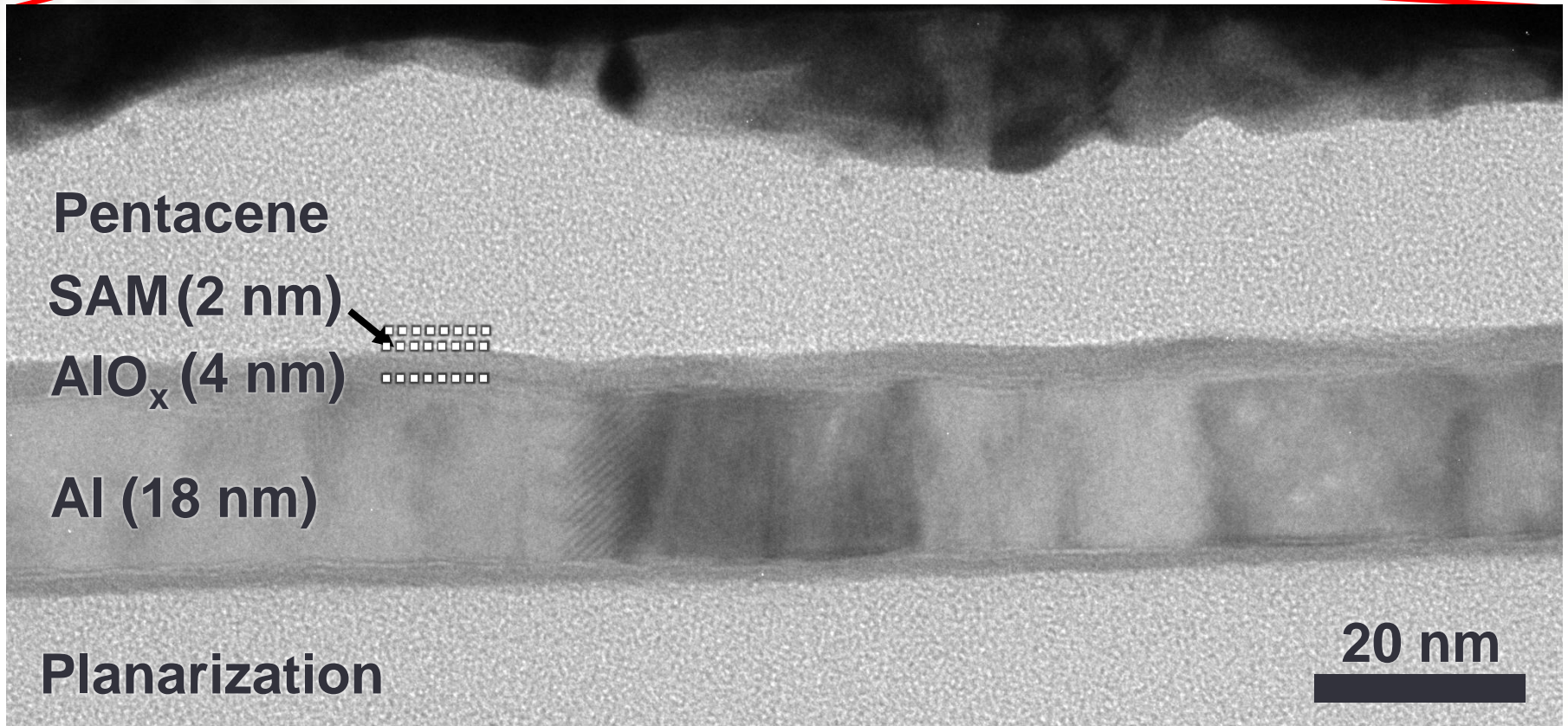
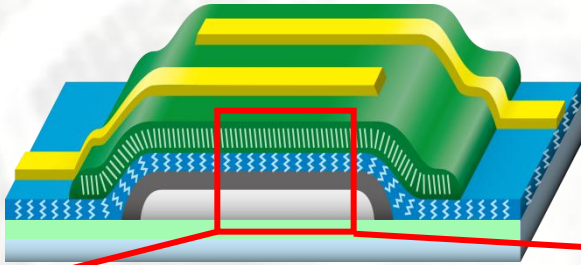


TFT: Neutral strain

AlO_x (4 nm)+SAMs (2 nm)
Klauk, et al., Nature 445 745 (2007)

Cross-sectional picture

(FIB/TEM)



Pentacene

SAM (2 nm)

AlO_x (4 nm)

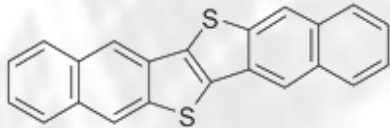
Al (18 nm)

Planarization

20 nm

Organic TFTs on plastic

P-type DNTT TFT

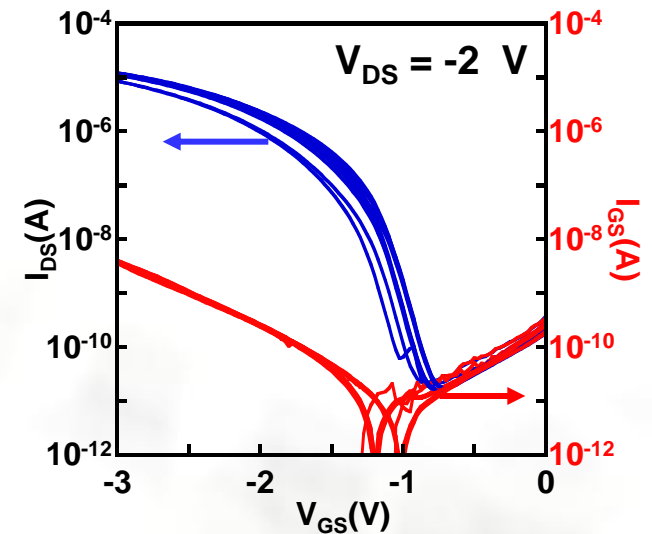
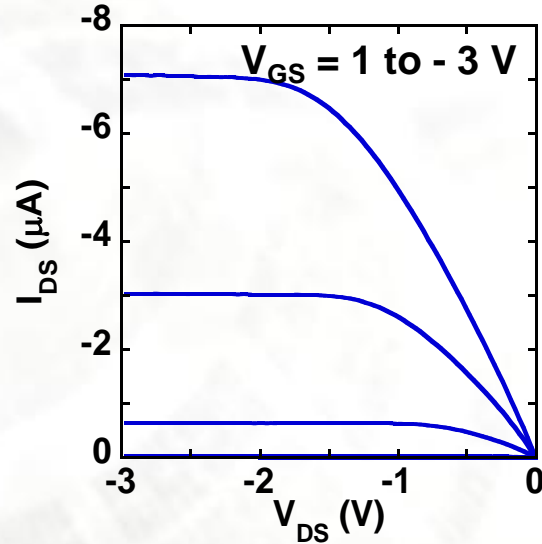


JACS 129, 2224 (2007).

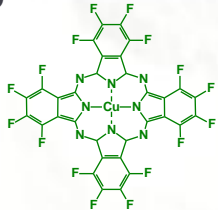
3.0 cm²/Vs

On/off: > 10⁵

80 mV/dec



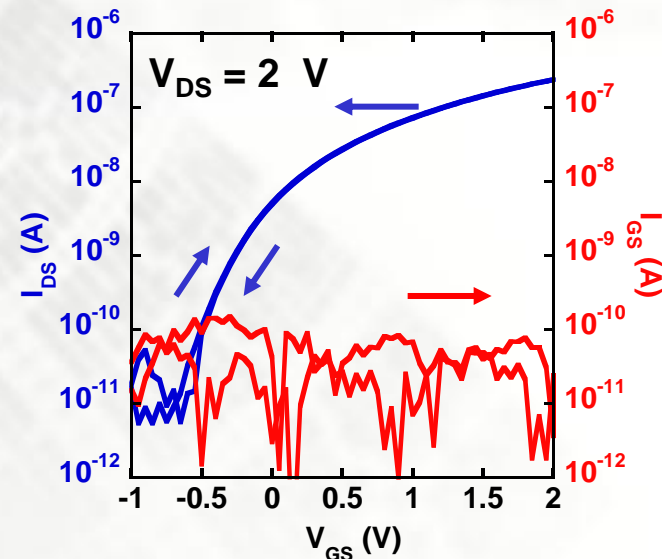
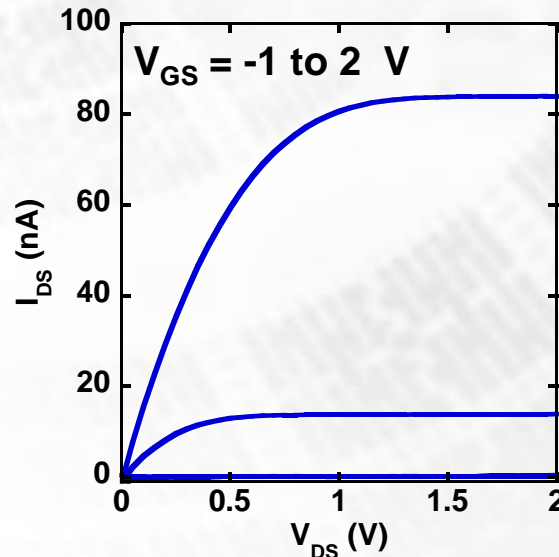
N-type F₁₆CuPc TFT



0.02 cm²/Vs

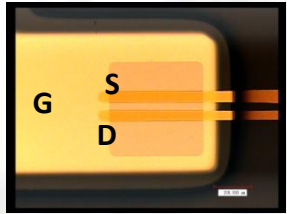
On/off: > 10⁴

150 mV/dec



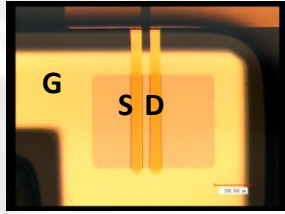
Bending test

Current // Strain
(Parallel)

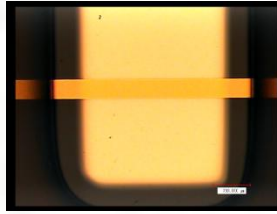


W/L = 500/50
(μm)

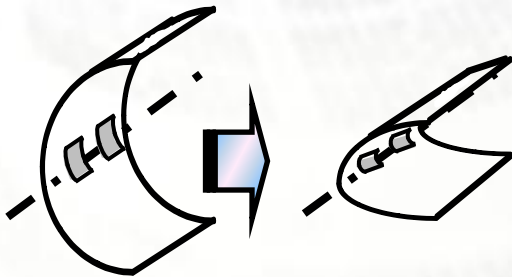
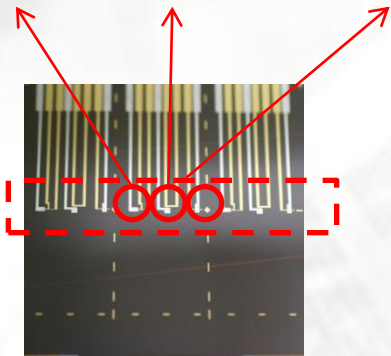
Current \perp Strain
(Perpendicular)



Capacitor

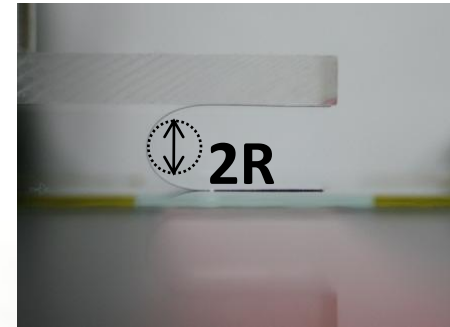


700 \times 100
(μm)

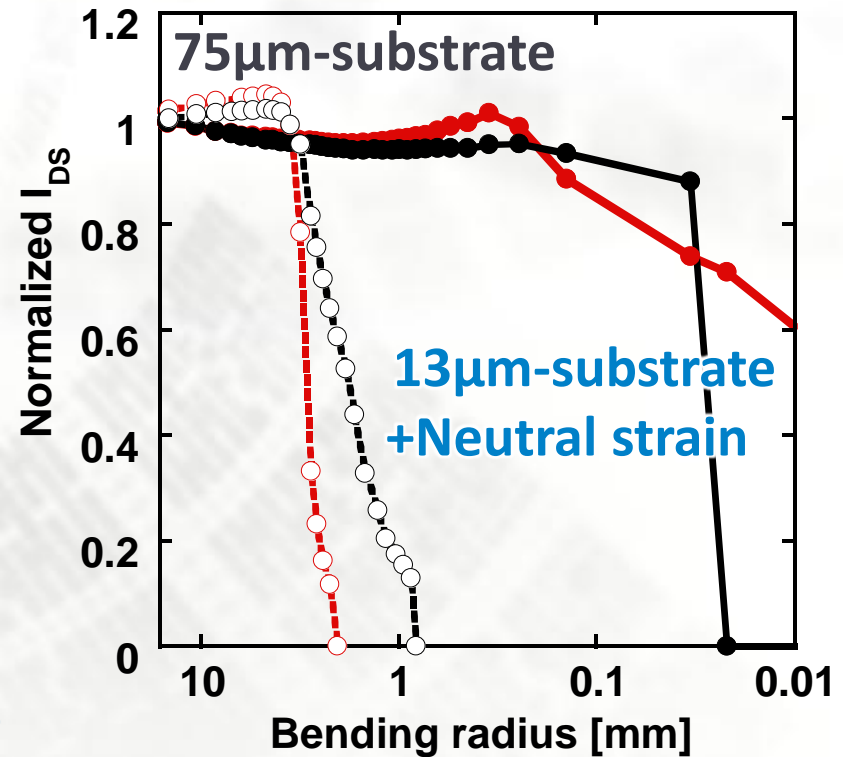


$R < 0.5 \text{ mm}$ (13 μm -thick substrate)
 $R \sim 4.0 \text{ mm}$ (75 μm -thick substrate)

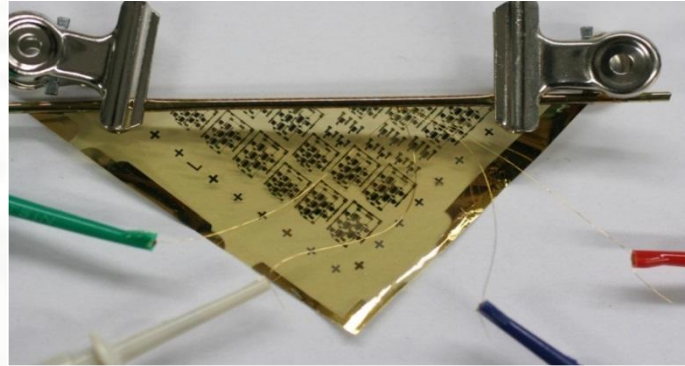
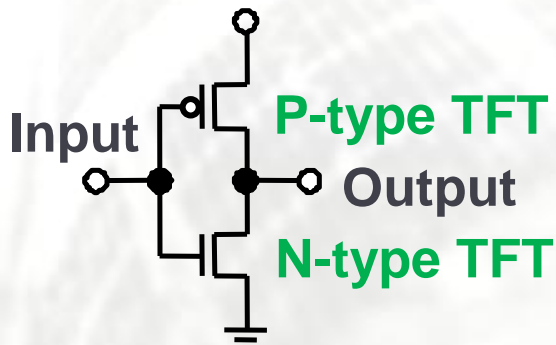
Cross-section



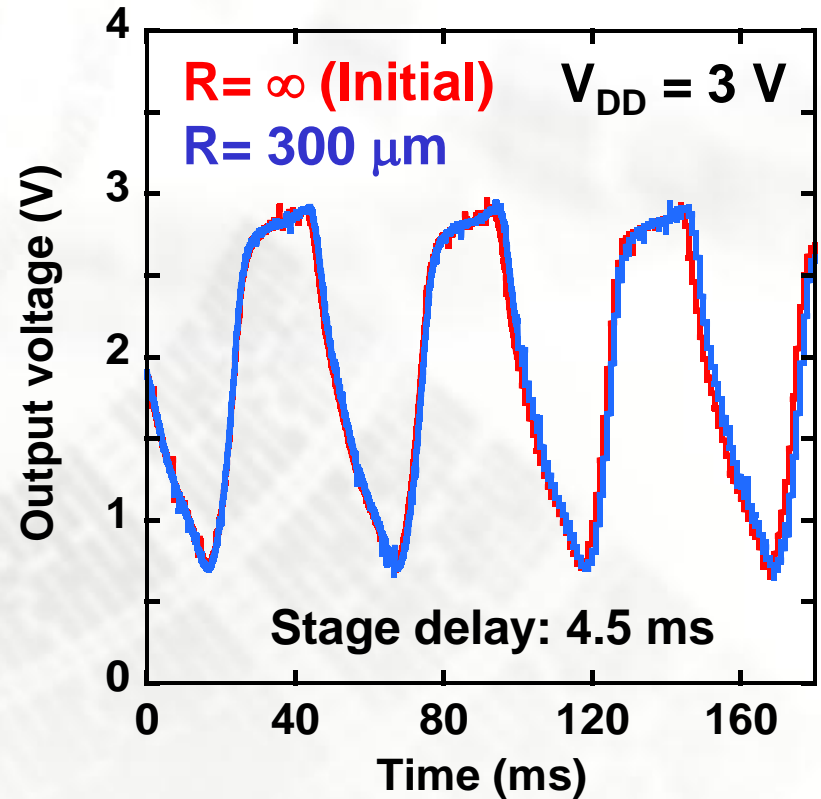
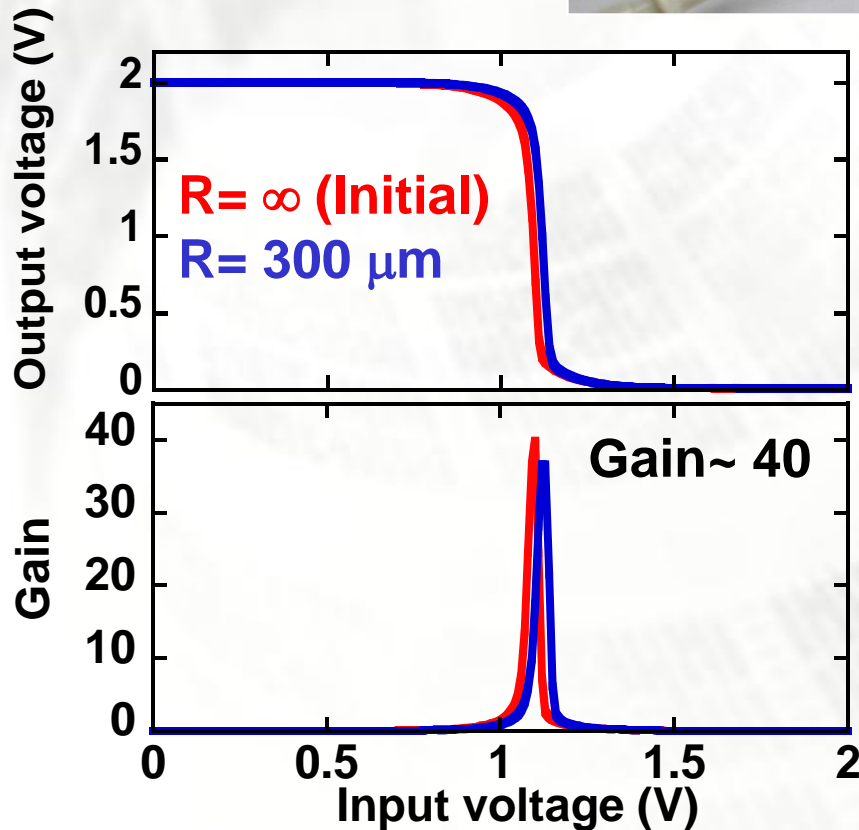
5mm



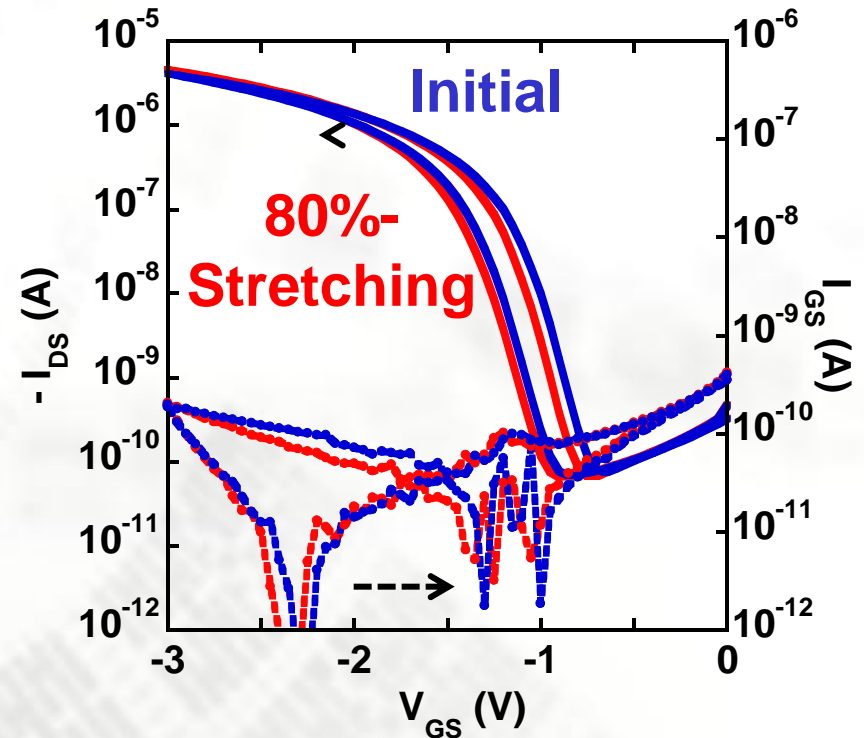
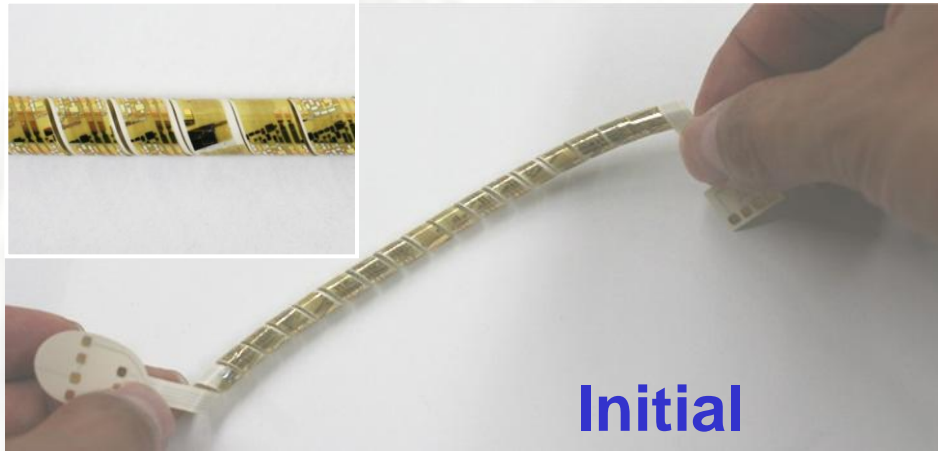
Organic CMOS circuits



- ✓ Inverter
- ✓ Ring oscillator

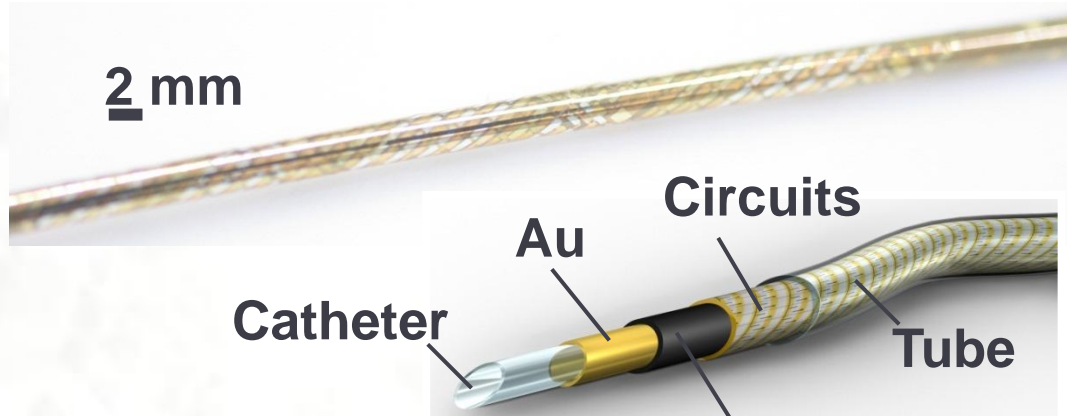
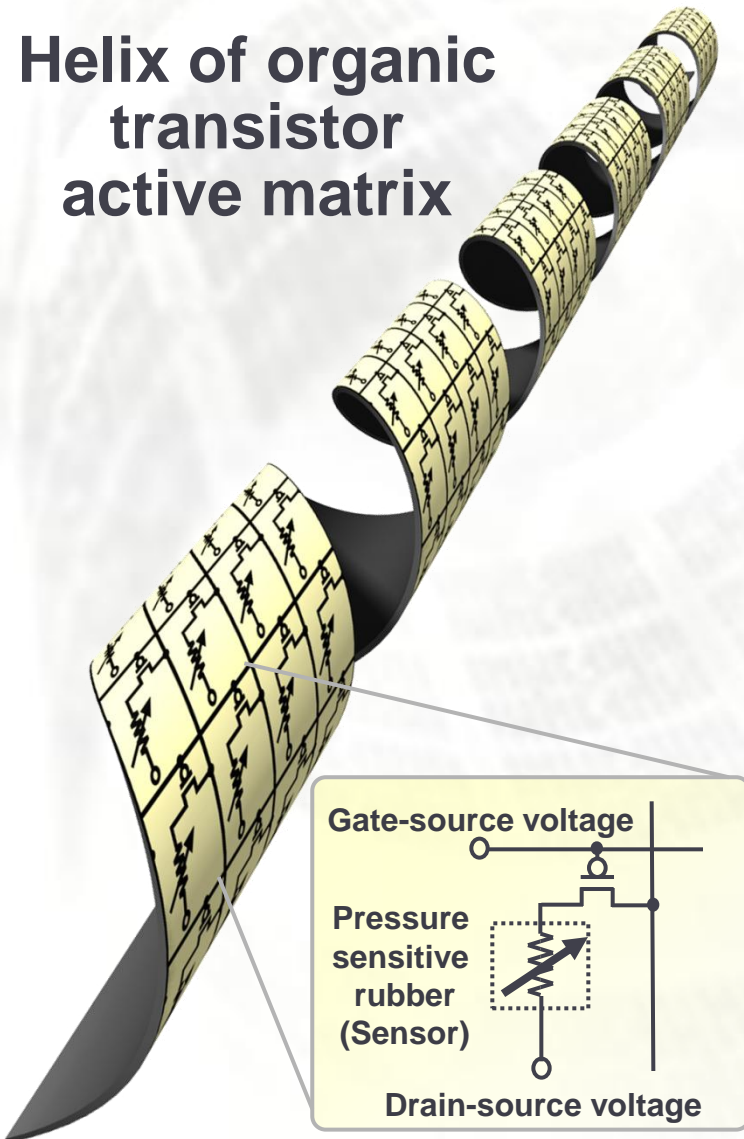


Stretchable integrated circuits on shape-memory polymer

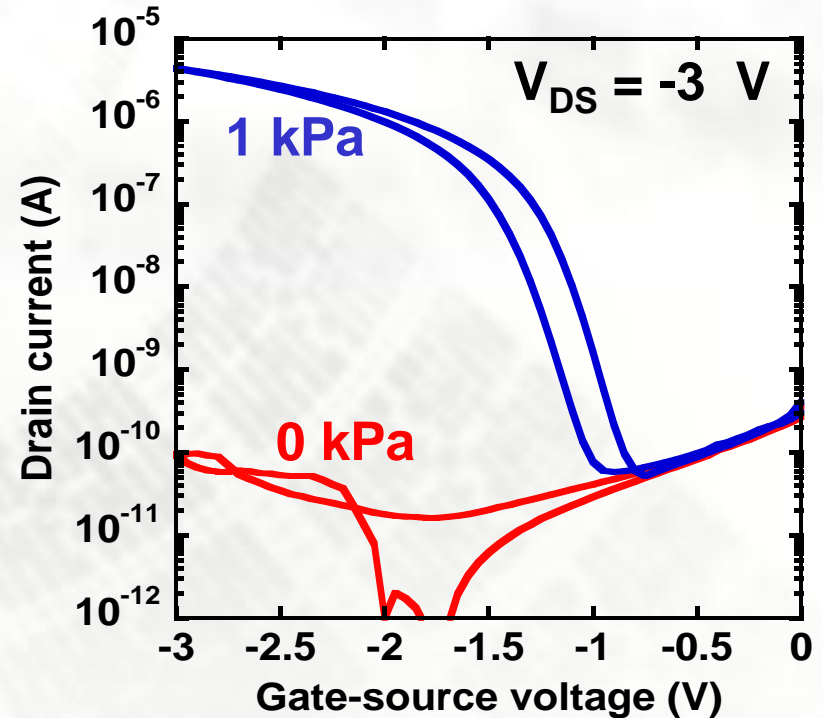


Fine-tube electronics for medical

Helix of organic transistor active matrix



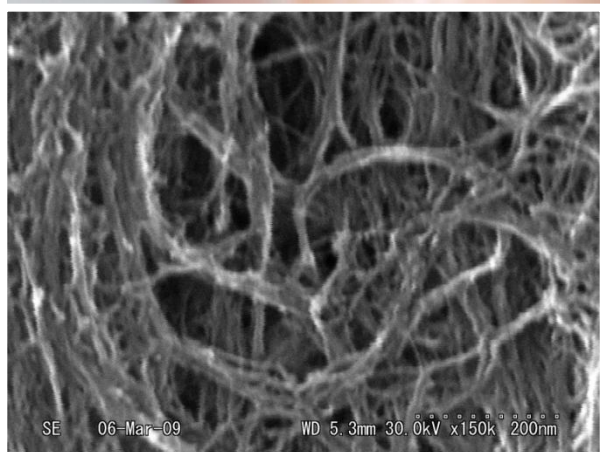
Pressure sensitive rubber



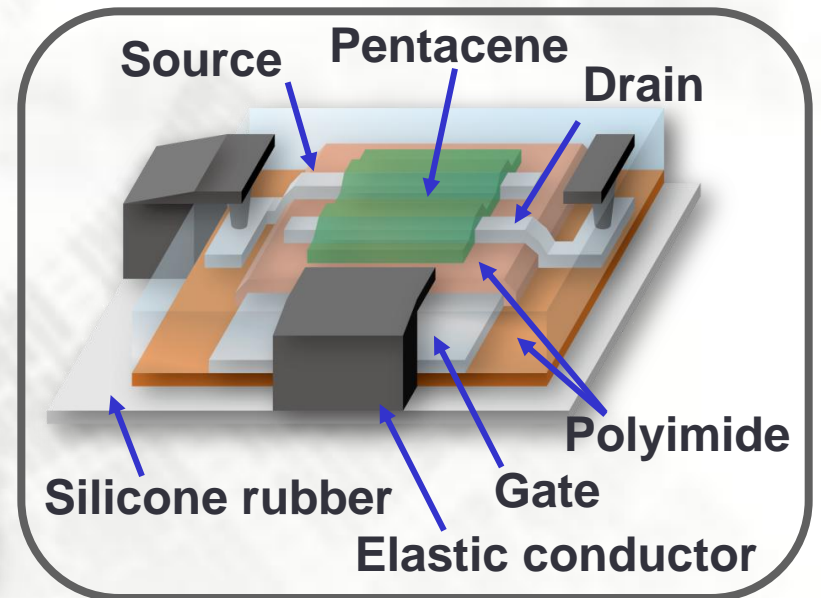
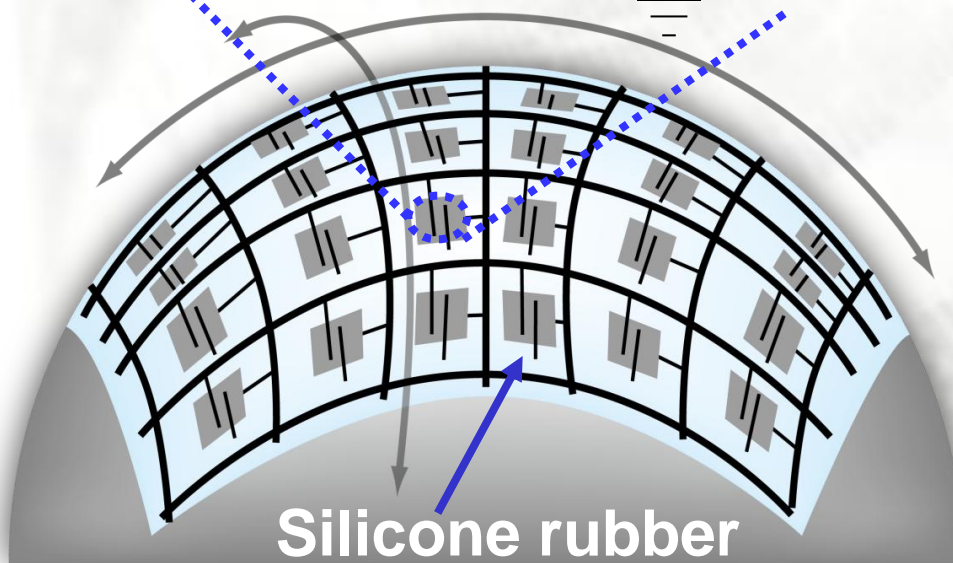
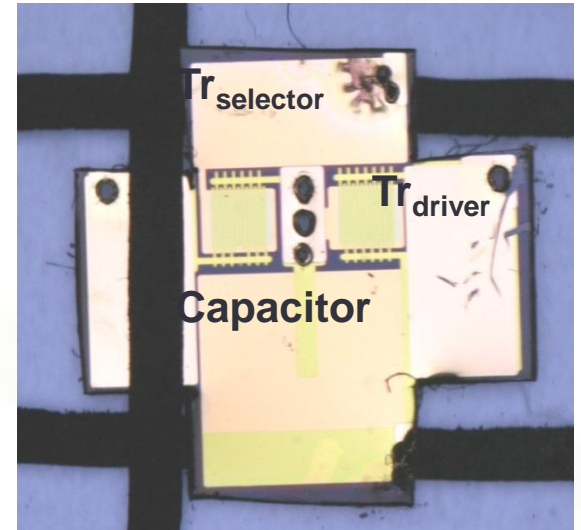
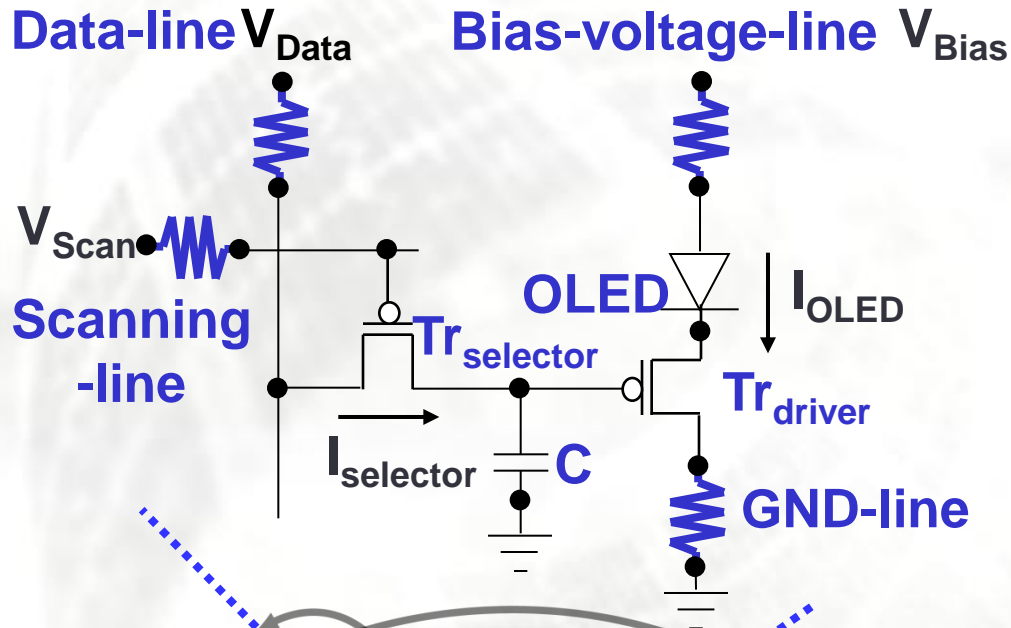
Printed elastic conductor

[Science 321, 1468 \(2008\).](#)

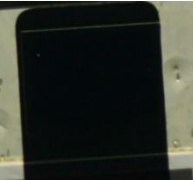
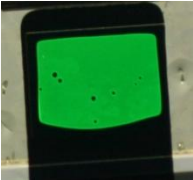
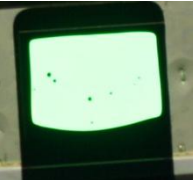



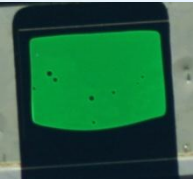



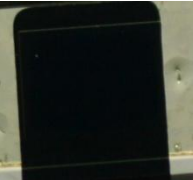
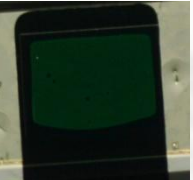
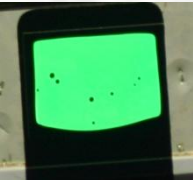
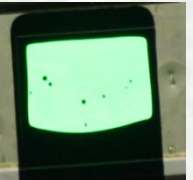
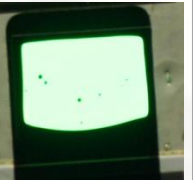
Resolution: $100\ \mu\text{m}$
Conductivity: $\sim 100\ \text{S/cm}$
Stretchability: $\sim 140\%$

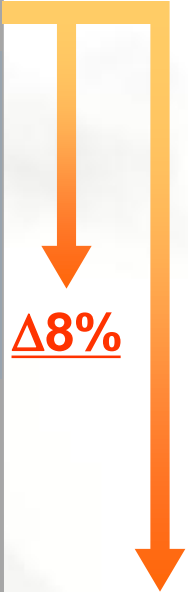


Structure for stretchable displays



Luminance of organic LEDs with organic driving cell

V_{Scan}	+40 V	-5 V	-10 V	-30 V	-40 V
Cu wiring (Control sample)	6.7 nA  0.0 cd/m ²	1.7 μA  0.3 cd/m ²	35 μA  6.1 cd/m ²	381 μA  88.3 cd/m ²	1.3 mA  408 cd/m ²
Elastic conductor	7.0 nA  0.0 cd/m ²	1.6 μA  0.28 cd/m ²	31.6 μA  5.5 cd/m ²	343 μA  77.2 cd/m ²	1.2 mA  364 cd/m ²
Conventional conducting rubber	2.6 nA  0.0 cd/m ²	280 nA  0.0 cd/m ²	6.6 μA  1.2 cd/m ²	19.4 μA  3.4 cd/m ²	40 μA  7.1 cd/m ²

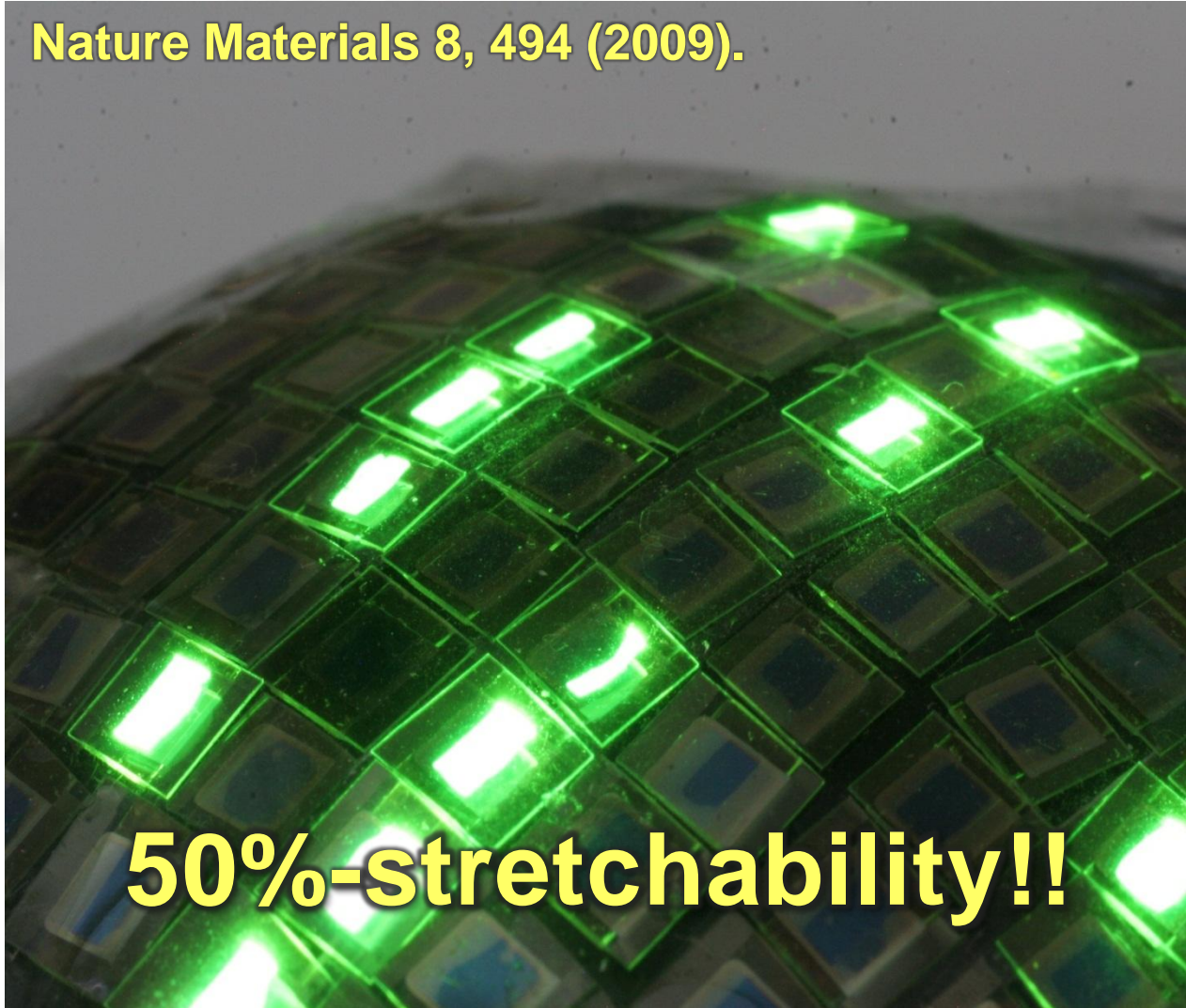


Δ8%

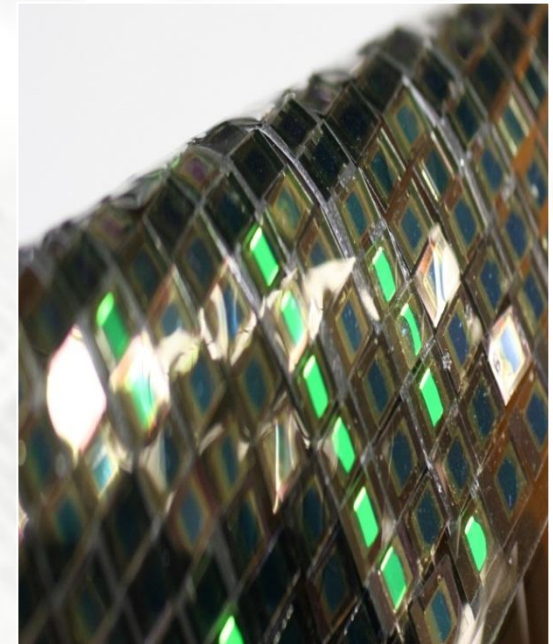
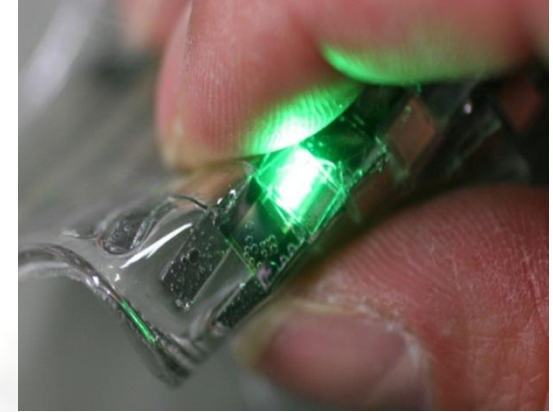
Δ97%

Stretchable active matrix OLED display

Nature Materials 8, 494 (2009).

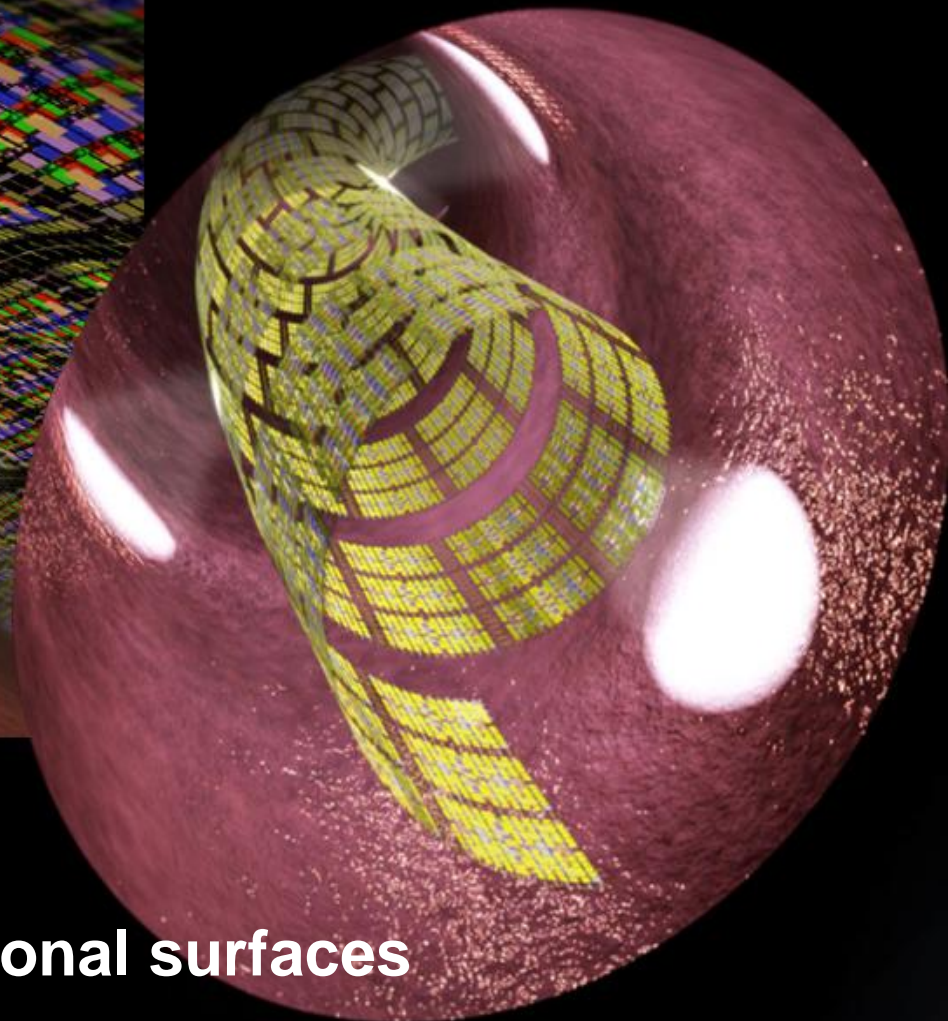
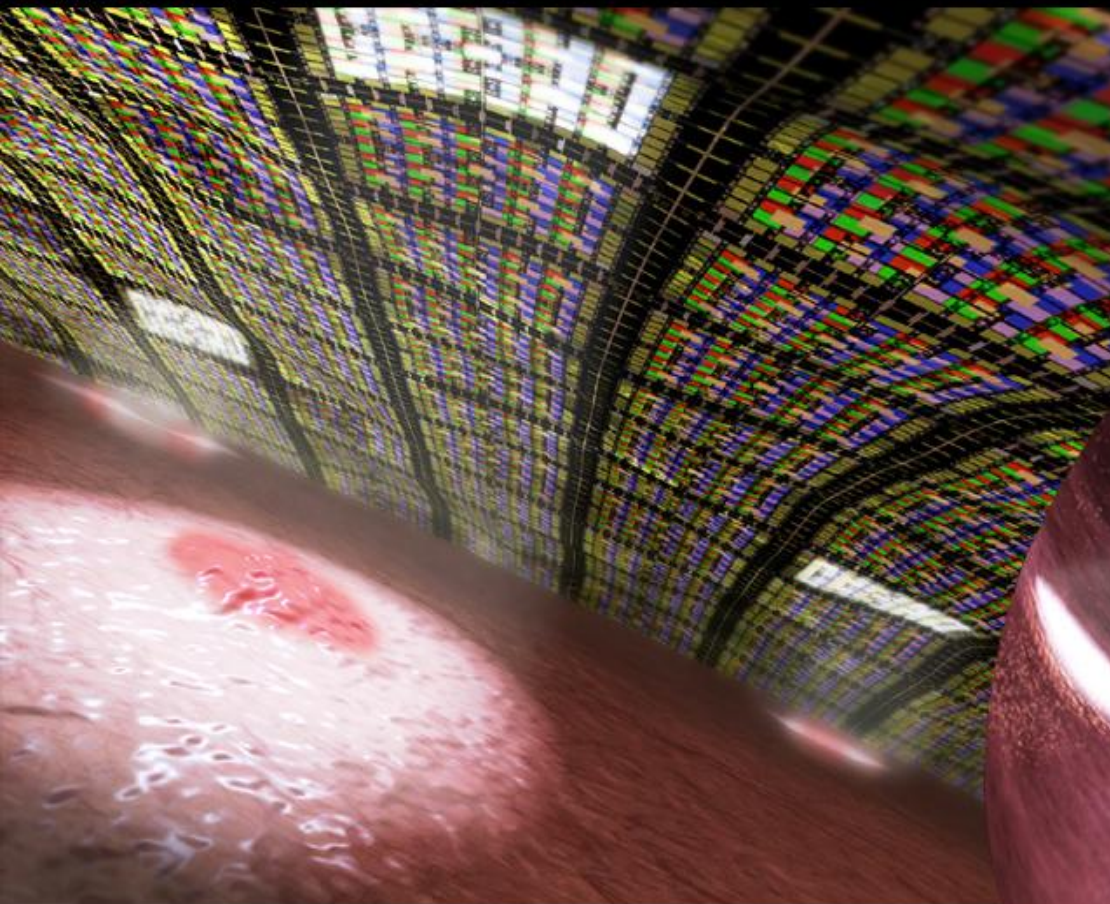


50%-stretchability!!



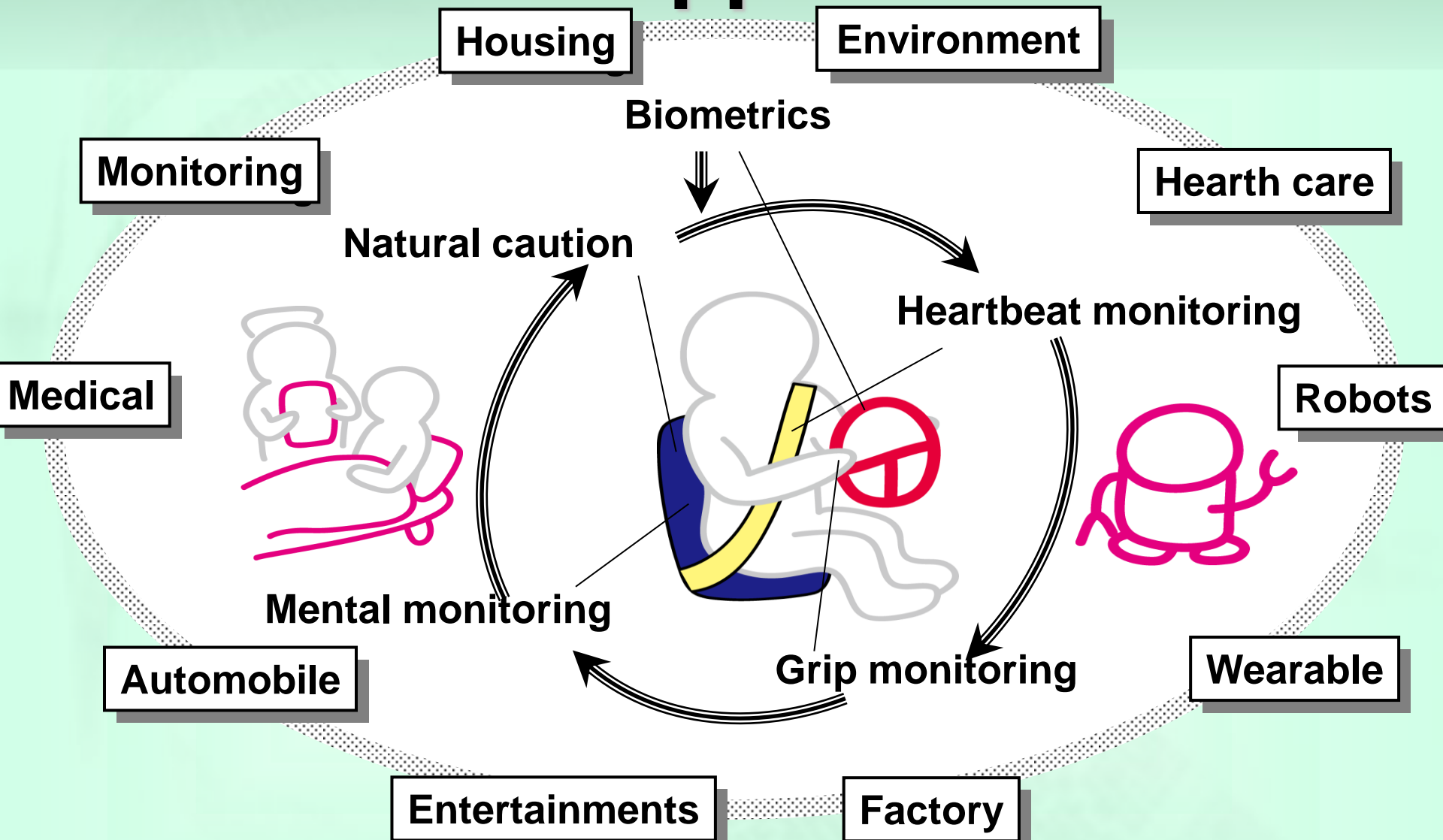
Displays on an egg.

Ultraflexible sensor & lighting for bio/medical applications



**Sensing and medical treatment
in blood vessel and unconventional surfaces**

New applications



Stretchable, large-area electronics using organics can cover arbitrary curved surfaces and movable parts, and thus would significantly expand where electronics can be used.

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Summary

- ✓ **All-printed organic transistors**
Solution-semiconductor: $0.18 \text{ cm}^2/\text{Vs}$, on/off $\sim 10^6$
- ✓ **Printed transistor active matrix**
 $300 \times 300 \text{ mm}^2$ (14,400 cells: 1mm pitch)
Large-area flexible touch-sensor system
- ✓ **Organic TFTs with SAM gate dielectric on thin films**
P-type DNTT TFT : $3.0 \text{ cm}^2/\text{Vs}$, On/off: $> 10^5$, 80 mV/dec
N-type F_{16}CuPc TFT : $0.02 \text{ cm}^2/\text{Vs}$, On/off: $> 10^4$, 150 mV/dec
- ✓ **Ultraflexible Organic CMOS circuits**
Inverter : Gain ~ 40 , Ring Oscillator : 4.5 ms (stage delay)
Medical sensors and display applications
- ✓ **Stretchable electronics**
Stretchable active matrix OLED display on curved surface